

Reexamination of spin decoherence in semiconductor quantum dots from the equation-of-motion approach

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The longitudinal and transversal spin decoherence times, T_1 and T_2 , in semiconductor quantum dots are investigated from the equation-of-motion approach for different magnetic fields, quantum dot sizes, and temperatures. Various mechanisms, such as the hyperfine interaction with the surrounding nuclei, the Dresselhaus spin-orbit coupling together with the electron-bulk-phonon interaction, the g -factor fluctuations, the direct spin-phonon coupling due to the phonon-induced strain, and the coaction of the electron-bulk- and/or surface-phonon interaction together with the hyperfine interaction are included. The relative contributions from these spin decoherence mechanisms are compared in detail. In our calculation, the spin-orbit coupling is included in each mechanism and is shown to have marked effect in most cases. The equation-of-motion approach is applied in studying both the spin relaxation time T_1 and the spin dephasing time T_2 , either in Markovian or in non-Markovian limit. When many levels are involved at finite temperature, we demonstrate how to obtain the spin relaxation time from the Fermi golden rule in the limit of weak spin-orbit coupling. However, at high temperature and/or for large spin-orbit coupling, one has to use the equation-of-motion approach when many levels are involved. Moreover, spin dephasing can be much more efficient than spin relaxation at high temperature, though the two only differ by a factor of 2 at low temperature.

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I. INTRODUCTION

One of the most important issues in the growing field of spintronics is quantum information processing in quantum dots (QDs) using electron spin.^{1–5} A main obstacle is that the electron spin is unavoidably coupled to the environment (such as the lattice) which leads to considerable spin decoherence (including longitudinal and transversal spin decoherences).^{6,7} Various mechanisms such as the hyperfine interaction with the surrounding nuclei,^{8,9} the Dresselhaus and/or Rashba spin-orbit coupling (SOC)^{10,11} together with the electron-phonon interaction, g -factor fluctuations,¹² the direct spin-phonon coupling due to the phonon-induced strain,⁹ and the coaction of the hyperfine interaction and the electron-phonon interaction can lead to the spin decoherence. There are quite a lot of theoretical works on spin decoherence in QD. Specifically, Khaetskii and Nazarov analyzed the spin-flip transition rate using a perturbative approach due to the SOC together with the electron-phonon interaction, g -factor fluctuations, and the direct spin-phonon coupling due to the phonon-induced strain qualitatively.^{13–15} After that, the longitudinal spin decoherence time T_1 due to the Dresselhaus and/or the Rashba SOC together with the electron-phonon interaction was studied quantitatively in Refs. 16–26. Among these works, Cheng *et al.*¹⁸ developed an exact diagonalization method and showed that due to the strong SOC, the previous perturbation method^{14–16} is inadequate in describing T_1 . Furthermore, they also showed that the perturbation method previously used missed an important second-order energy correction and would yield qualitatively wrong results if the energy correction is correctly included and only the lowest few states are kept as those in Refs. 14–16. These results were later confirmed by Destefani and

Ulloa.²¹ The contribution of the coaction of the hyperfine interaction and the electron-phonon interaction to longitudinal spin decoherence was calculated in Refs. 27 and 28. In contrast to the longitudinal spin decoherence time, there are relatively fewer works on the transversal spin decoherence time T_2 , also referred to as the spin dephasing time (while the longitudinal spin decoherence time is referred to as the spin relaxation time for short). The spin dephasing time due to the Dresselhaus and/or the Rashba SOC together with the electron-phonon interaction was studied by Semenov and Kim²⁹ and by Golovach *et al.*²⁰ The contributions of the hyperfine interaction and the g -factor fluctuation were studied in Refs. 30–44 and in Ref. 45, respectively. However, a quantitative calculation of electron spin decoherence induced by the direct spin-phonon coupling due to phonon-induced strain in QDs is still missing. This is one of the issues we are going to present in this paper. In brief, the spin relaxation (dephasing) due to various mechanisms has been studied previously in many theoretical works. However, almost all of these works only focus individually on one mechanism. Khaetskii and Nazarov discussed the effects of different mechanisms on the spin relaxation time. Nevertheless, their results are only qualitative and there is no comparison of the relative importance of the different mechanisms.^{13–15} Recently, Semenov and Kim discussed various mechanisms contributed to the spin dephasing,⁴⁶ where they gave a “phase diagram” to indicate the most important spin dephasing mechanism in Si QD where the SOC is not important. However, the SOC is very important in GaAs QDs. To fully understand the microscopic mechanisms of spin relaxation and dephasing and to achieve control over the spin coherence in QDs,^{47–49} one needs to gain insight into the relative importance of each mechanism to T_1 and T_2 under various conditions. This is one of the main purposes of this paper.

Another issue we are going to address relates to different approaches used in the study of the spin relaxation time. The Fermi-golden-rule approach, which is widely used in the literature, can be used in the calculation of the relaxation time $\tau_{i \rightarrow f}$ between any initial state $|i\rangle$ and final state $|f\rangle$.^{12–19,21,23–25,27,28,50–52} However, the problem is that when the process of the spin relaxation relates to many states (e.g., when temperature is high, the electron can distribute over many states), one should find a proper way to average over the relaxation times ($\tau_{i \rightarrow f}$) of the involved processes to give the total spin relaxation time (T_1). What makes it difficult in GaAs QDs is that all the states are *impure* spin states with *different* expectation values of spin. In the existing literature, spin relaxation time is given by the average of the relaxation times of processes from the initial state $|i\rangle$ to the final state $|f\rangle$ (with opposite majority spin of $|i\rangle$) weighted by the distribution of the initial states f_i ,^{18,51,52} i.e.,

$$T_1^{-1} = \sum_{if} f_i \tau_{i \rightarrow f}^{-1}. \quad (1)$$

This is a good approximation in the limit of small SOC as each state only carries a small amount of minority spin. However, when the SOC is very strong which happens at high levels, it is difficult to find the proper way to perform the average. We will show that Eq. (1) is not adequate anymore. Thus, to investigate both T_1 and T_2 at finite temperature for arbitrary strength of SOC, we develop an equation-of-motion approach for the many-level system via projection operator technique⁵⁶ in the Born approximation. With the rotating wave approximation, we obtain a formal solution to the equation of motion. By assuming a proper initial distribution, we can calculate the evolution of the expectation value of spin. We thus obtain the spin relaxation (dephasing) time by the $1/e$ decay of the expectation value of spin operator $\langle S_z \rangle$ or $| \langle S_+ \rangle |$ (to its equilibrium value), with $S_{\pm} \equiv S_x \pm iS_y$. With this approach, we are able to study spin relaxation (dephasing) for various temperatures, SOC strengths, and magnetic fields.

For quantum information processing based on electron spin in QDs, the quantum phase coherence is very important. Thus, the spin dephasing time is a more relevant quantity. There are two kinds of spin dephasing times: the ensemble spin dephasing time T_2^* and the irreversible spin dephasing time T_2 . For a direct measurement of an ensemble of QDs⁵⁸ or an average over many measurements at different times where the configurations of the environment have been changed,^{59–61} it gives the ensemble spin dephasing time T_2^* . The irreversible spin dephasing time T_2 can be obtained by spin echo measurement.^{60,61} A widely discussed source which leads to both T_2^* and T_2 is the hyperfine interaction between the electron spin and the nuclear spins of the lattice. It has been found that T_2^* is around 10 ns, which is too short and makes a practical quantum information processing difficult in electron spin based qubits in QDs. Thus, a spin echo technique is needed to remove the free induction decay and to elongate the spin dephasing time. Fortunately, this technique has been achieved first by Petta *et al.* for a two electron triplet-singlet system and then by Koppens *et al.* for a single electron spin system. The achieved spin dephasing

time is $\sim 1 \mu\text{s}$, which is much longer than T_2^* . We therefore discuss only the irreversible spin dephasing time T_2 throughout the paper, i.e., we do not consider the free induction decay in the hyperfine-interaction-induced spin dephasing.

It is further noticed that Golovach *et al.* have shown that the spin dephasing time T_2 is two times the spin relaxation time T_1 .²⁰ However, as temperature increases, this relation does not hold. Semenov and Kim, on the other hand, reported that the spin dephasing time is much smaller than the spin relaxation time.²⁹ In this paper, we calculate the temperature dependence of the ratio of the spin relaxation time to the spin dephasing time and analyze the underlying physics.

This paper is organized as follows. In Sec. II, we present our model and formalism of the equation-of-motion approach. We also briefly introduce all the spin decoherence mechanisms considered in our calculations. In Sec. III, we present our numerical results to indicate the contribution of each spin decoherence mechanism to spin relaxation (dephasing) time under various conditions based on the equation-of-motion approach. Then, we study the problem of how to obtain the spin relaxation time from the Fermi golden rule when many levels are involved in Sec. IV. The temperature dependence of T_1 and T_2 is investigated in Sec. V. We conclude in Sec. VI.

II. MODEL AND FORMALISM

A. Model and Hamiltonian

We consider a QD system, where the QD is confined by a parabolic potential $V_c(x, y) = \frac{1}{2} m^* \omega_0^2 (x^2 + y^2)$ in the quantum well plane. The width of the quantum well is a . The external magnetic field \mathbf{B} is along the z direction, except in Sec. IV. The total Hamiltonian of the system of electron together with the lattice is

$$H_T = H_e + H_L + H_{eL}, \quad (2)$$

where H_e , H_L , and H_{eL} are the Hamiltonians of the electron, the lattice, and their interaction, respectively. The electron Hamiltonian is given by

$$H_e = \frac{\mathbf{P}^2}{2m^*} + V_c(\mathbf{r}) + H_Z + H_{SO}, \quad (3)$$

where $\mathbf{P} = -i\hbar \nabla + \frac{e}{c} \mathbf{A}$ with $\mathbf{A} = (\mathbf{B}_{\perp} / 2)(-\mathbf{y}, \mathbf{x})$ (B_{\perp} is the magnetic field along the z direction), $H_Z = \frac{1}{2} g \mu_B \mathbf{B} \cdot \boldsymbol{\sigma}$ is the Zeeman energy with μ_B the Bohr magneton, and H_{SO} is the Hamiltonian of SOC. In GaAs, when the quantum well width is small or the gate voltage along the growth direction is small, the Rashba SOC is unimportant.⁵³ Therefore, only the Dresselhaus term¹⁰ contributes to H_{SO} . When the quantum well width is smaller than the QD radius, the dominant term in the Dresselhaus SOC reads

$$H_{so} = \frac{\gamma_0}{\hbar^3} \langle P_z^2 \rangle_{\lambda_0} (-P_x \sigma_x + P_y \sigma_y), \quad (4)$$

with γ_0 denoting the Dresselhaus coefficient, λ_0 being the quantum well subband index of the lowest one, and

$\langle P_z^2 \rangle_\lambda \equiv -\hbar^2 \int \psi_{z\lambda}^*(z) \partial^2 / \partial z^2 \psi_{z\lambda}(z) dz$. The Hamiltonian of the lattice consists of two parts, $H_L = H_{ph} + H_{nuclei}$, where $H_{ph} = \sum_{\mathbf{q}\gamma} \hbar \omega_{\mathbf{q}\gamma} a_{\mathbf{q}\gamma}^\dagger a_{\mathbf{q}\gamma}$ [$a^\dagger(a)$ is the phonon creation (annihilation) operator] describes the vibration of the lattice, and $H_{nuclei} = \sum_j \gamma_j \mathbf{B} \cdot \mathbf{I}_j$ (γ_j is the gyromagnetic ratios of the nuclei and \mathbf{I}_j is the spin of the j th nucleus) describes the precession of the nuclear spins of the lattice in the external magnetic field. We focus on the spin dynamics due to hyperfine interaction at a time scale much smaller than the nuclear dipole-dipole correlation time [10^{-4} s in GaAs (Refs. 33 and 40)], where the nuclear dipole-dipole interaction can be ignored. Under this approximation, the equation of motion for the reduced electron system can be obtained which only depends on the initial distribution of the nuclear spin bath.³³ The interaction between the electron and the lattice also has two parts $H_{eL} = H_{eI} + H_{e-ph}$, where H_{eI} is the hyperfine interaction between the electron and nuclei and H_{e-ph} represents the electron-phonon interaction which is further composed of the electron-bulk-phonon (BP) interaction H_{ep} , the direct spin-phonon coupling due to the phonon-induced strain H_{strain} and phonon-induced g -factor fluctuation H_g .

B. Equation-of-motion approach

The equations of motion can describe both the coherent and the dissipative dynamics of the electron system. When the quasiparticles of the bath relax much faster than the electron system, the Markovian approximation can be made; otherwise, the kinetics is the non-Markovian. For electron-phonon coupling, due to the fast relaxation of the phonon bath and the weak electron-phonon scattering, the kinetics of the electron is Markovian. Nevertheless, as the nuclear spin bath relaxes much slower than the electron spin, the kinetics due to the coupling with nuclei is of non-Markovian type.^{30,32,33} It is further noted that there is also a contribution from the coaction of the electron-phonon and electron-nuclei couplings, which is a fourth-order coupling to the bath. For this contribution, the decoherence of spin is mainly controlled by the electron-phonon scattering, while the hyperfine (Overhauser) field⁵⁴ acts as a static magnetic field. Thus, this fourth-order coupling is also Markovian. Finally, since the electron orbit relaxation is much faster than the electron spin relaxation,⁵⁵ we always assume a thermoequilibrium initial distribution of the orbital degrees of freedom.

Generally, the interaction between the electron and the quasiparticle of the bath is weak. Therefore, the first Born approximation is adequate in the treatment of the interaction. Under this approximation, the equation of motion for the electron system coupled to the lattice environment can be obtained with the help of the projection operator technique.⁵⁶ We then assume a sudden approximation so that the initial distribution of the whole system is $\rho(t=0) = \rho^e(0) \otimes \rho^L(0)$, where ρ^e and ρ^L are the density matrix of the system and of the bath, respectively. This approximation corresponds to a sudden injection of the electron into the quantum dot, which is reasonable for the genuine experimental setup.³³ As the initial distribution of the the lattice $\rho^L(0)$ commutes with the Hamiltonian of the lattice H_L , the equation of motion can be written as

$$\begin{aligned} \frac{d\rho^e(t)}{dt} = & -\frac{i}{\hbar} [H_e + \text{Tr}_L[H_{eL}\rho^L(0)], \rho^e(t)] \\ & - \frac{1}{\hbar^2} \int_0^t d\tau \text{Tr}_L([H_{eL}, U_0(\tau) \{ \hat{P}[H_{eL}, \rho^e(t-\tau)] \\ & \otimes \rho^L(0) \} U_0^\dagger(\tau)]), \end{aligned} \quad (5)$$

where $\rho^e(t)$ is the density operator of the electron system at time t , Tr_L stands for the trace over the lattice degree of freedom, and $U_0(\tau) = e^{-i(H_L + H_e)\tau}$ is time-evolution operator without H_{eL} . $\hat{P} = \hat{1} - \rho^L(0) \otimes \text{Tr}_L$ is the projection operator. The initial distribution of the phonon system is chosen to be the thermoequilibrium distribution.²⁰ It has been shown by previous theoretical studies that the initial state of the nuclear spin bath is crucial to the spin dephasing and relaxation.^{30,32,33} Although it may take a long time (e.g., seconds) for the nuclear spin system to relax to its thermoequilibrium state, one can still assume that its initial state is the thermoequilibrium one. This assumption corresponds to the genuine case of long enough waiting time during every individual measurement. For a typical setup at above 10 mK and with about 10 T external magnetic field, the thermoequilibrium distribution is a distribution with equal probability on every state. For these initial distributions of phonons and nuclear spins, the term $\text{Tr}_L[H_{eL}\rho^L(0)]$ is zero. Thus,

$$\hat{P}[H_{eL}, \rho^e(t-\tau) \otimes \rho^L(0)] = [H_{eL}, \rho^e(t-\tau) \otimes \rho^L(0)]. \quad (6)$$

The equation of motion is then simplified to

$$\begin{aligned} \frac{d\rho^e(t)}{dt} = & -\frac{i}{\hbar} [H_e, \rho^e(t)] - \frac{1}{\hbar^2} \int_0^t d\tau \text{Tr}_L \\ & \times \{ [H_{eL}, [H_{eL}^I(-\tau), U_0^e(t) \rho^e(t-\tau) U_0^{e\dagger}(t) \rho^L(0)]] \}, \end{aligned} \quad (7)$$

where H_{eL}^I and ρ^{Le} are the corresponding operators (H_{eL} and ρ^e) in the interaction picture and $U_0^e(t) = e^{-iH_e t}$ is the time-evolution operator of H_e . It should be further noted that the first Born approximation cannot fully account for the non-Markovian dynamics due to the hyperfine interaction with nuclear spins.^{33,57} Only when the Zeeman splitting is much larger than the fluctuating Overhauser shift the first Born approximation is adequate. For GaAs QDs, this requires $B \gg 3.5$ T.³³ In this paper, we focus on the study of spin dephasing for the high magnetic field regime of $B > 3.5$ T under the first Born approximation, where the second Born approximation only affects the long-time behavior.³³ Later, we will argue that this correction of long-time dynamics changes the spin dephasing time very little.

1. Markovian kinetics

The kinetics due to the coupling with phonons can be investigated within the Markovian approximation, where the equation of motion reduces to

$$\frac{d\rho^e(t)}{dt} = -\frac{i}{\hbar}[H_e, \rho^e(t)] - \frac{1}{\hbar^2} \int_0^t d\tau \times \text{Tr}_{ph} \{ [H_{e-ph}, [H_{e-ph}^\dagger(-\tau), \rho^e(t) \otimes \rho^{ph}(0)]] \}. \quad (8)$$

Here, Tr_{ph} is the trace over phonon degrees of freedom and $\rho^{ph}(0)$ is the initial distribution of the phonon bath. Within the basis of the eigenstates of the electron Hamiltonian, $\{|\ell\rangle\}$, the above equation reads

$$\begin{aligned} \frac{d}{dt} \rho_{\ell_1 \ell_2}^e &= -i \frac{(\varepsilon_{\ell_1} - \varepsilon_{\ell_2})}{\hbar} \rho_{\ell_1 \ell_2}^e \\ &- \left\{ \frac{1}{\hbar^2} \int_0^t d\tau \sum_{\ell_3 \ell_4} \text{Tr}_p (H_{\ell_1 \ell_3}^{e-ph} H_{\ell_3 \ell_4}^{\dagger e-ph} \rho_{\ell_4 \ell_2}^e \otimes \rho_{e q}^p \right. \\ &\left. - H_{\ell_1 \ell_3}^{\dagger e-ph} \rho_{\ell_3 \ell_4}^e \otimes \rho_{e q}^p H_{\ell_4 \ell_2}^{e-ph}) + \text{H.c.} \right\}. \quad (9) \end{aligned}$$

Here, $H_{\ell_1 \ell_3}^{e-ph} = \langle \ell_1 | H_{e-ph} | \ell_3 \rangle$ and $H_{\ell_1 \ell_3}^{\dagger e-ph} = \langle \ell_1 | H_{e-ph}^\dagger(-\tau) | \ell_3 \rangle$. A general form of the electron-phonon interaction reads

$$H_{e-ph} = \sum_{q\eta} \Phi_{q\eta} (a_{q\eta} + a_{-q\eta}^\dagger) X_{q\eta}(\mathbf{r}, \boldsymbol{\sigma}). \quad (10)$$

Here, η represents the phonon branch index, $\Phi_{q\eta}$ is the matrix element of the electron-phonon interaction, $a_{q\eta}$ is the phonon annihilation operator, and $X_{q\eta}(\mathbf{r}, \boldsymbol{\sigma})$ denotes a function of electron position and spin. Substituting this into Eq. (9), we obtain, after integration within the Markovian approximation,⁴⁹

$$\begin{aligned} \frac{d}{dt} \rho_{\ell_1 \ell_2}^e &= i \frac{(\varepsilon_{\ell_1} - \varepsilon_{\ell_2})}{\hbar} \rho_{\ell_1 \ell_2}^e \\ &- \left\{ \frac{\pi}{\hbar^2} \sum_{\ell_3 \ell_4} \sum_{q\eta} |\Phi_{q\eta}|^2 [X_{\ell_1 \ell_3}^{q\eta} X_{\ell_4 \ell_2}^{q\eta*} \rho_{\ell_4 \ell_3}^e C_{q\eta}(\varepsilon_{\ell_4} - \varepsilon_{\ell_3}) \right. \\ &\left. - X_{\ell_4 \ell_2}^{q\eta} X_{\ell_3 \ell_1}^{q\eta*} \rho_{\ell_3 \ell_4}^e C_{q\eta}(\varepsilon_{\ell_3} - \varepsilon_{\ell_1})] + \text{H.c.} \right\}, \quad (11) \end{aligned}$$

in which $X_{\ell_1 \ell_2}^{q\eta} = \langle \ell_1 | X_{q\eta}(\mathbf{r}, \boldsymbol{\sigma}) | \ell_2 \rangle$ and $C_{q\eta}(\Delta\varepsilon) = \bar{n}(\omega_{q\eta}) \delta(\Delta\varepsilon + \omega_{q\eta}) + [\bar{n}(\omega_{q\eta}) + 1] \delta(\Delta\varepsilon - \omega_{q\eta})$. Here, $\bar{n}(\omega_{q\eta})$ represents the Bose distribution function. Equation (11) can be written in a more compact form

$$\frac{d}{dt} \rho_{\ell_1 \ell_2}^e = - \sum_{\ell_3 \ell_4} \Lambda_{\ell_1 \ell_2 \ell_3 \ell_4} \rho_{\ell_3 \ell_4}^e, \quad (12)$$

which is a linear differential equation. This equation can be solved by diagonalizing Λ . Given an initial distribution $\rho_{\ell_1 \ell_2}^e(0)$, the density matrix $\rho_{\ell_1 \ell_2}^e(t)$ and the expectation value of any physical quantity $\langle O \rangle_t = \text{Tr}[\hat{O} \rho^e(t)]$ at time t can be obtained,⁴⁹

$$\begin{aligned} \langle O \rangle_t &= \text{Tr}(\hat{O} \rho^e) \\ &= \sum_{\ell_1 \dots \ell_6} \langle \ell_2 | \hat{O} | \ell_1 \rangle \mathbf{P}_{(\ell_1 \ell_2)(\ell_3 \ell_4)} e^{-\Gamma(\ell_3 \ell_4) t} \mathbf{P}_{(\ell_3 \ell_4)(\ell_5 \ell_6)}^{-1} \rho_{\ell_5 \ell_6}^e(0), \quad (13) \end{aligned}$$

with $\Gamma = \mathbf{P}^{-1} \Lambda \mathbf{P}$ being the diagonal matrix and \mathbf{P} representing the transformation matrix. To study spin dynamics, we calculate $\langle S_z \rangle_t$ ($|\langle S_+ \rangle_t|$) and define the spin relaxation (dephasing) time as the time when $\langle S_z \rangle_t$ ($|\langle S_+ \rangle_t|$) decays to $1/e$ of its initial value (to its equilibrium value).

2. Non-Markovian kinetics

Experiments have already shown that for a large ensemble of quantum dots or for an ensemble of many measurements on the same quantum dot at different times, the spin dephasing time due to hyperfine interaction is quite short, ~ 10 ns.^{58–61} This rapid spin dephasing is caused by the ensemble broadening of the precession frequency due to the hyperfine fields.⁴⁰ When the external magnetic field is much larger than the random Overhauser field, the rotation due to the Overhauser field perpendicular to the magnetic field is blocked. Only the broadening of the Overhauser field parallel to the magnetic field contributes to the spin dephasing. To describe this free induction decay for this high magnetic field case, we write the hyperfine interaction into two parts: $H_{eI} = \mathbf{h} \cdot \mathbf{S} = H_{eI1} + H_{eI2}$. Here $\mathbf{h} = (h_x, h_y, h_z)$ and $\mathbf{S} = (S_x, S_y, S_z)$ are the Overhauser field and the electron spin, respectively. $H_{eI1} = h_z S_z$ and $H_{eI2} = \frac{1}{2}(h_+ S_- + h_- S_+)$ with $h_{\pm} = h_x \pm ih_y$. The longitudinal part H_{eI1} is responsible for the free induction decay, while the transversal part H_{eI2} is responsible for high order irreversible decay. As the rapid free induction decay can be removed by spin echo,^{60,61} elongating the spin dephasing time to $\sim 1 \mu\text{s}$ which is more favorable for quantum computation and quantum information processing, we then discuss only the irreversible decay. We first classify the states of the nuclear spin system with its polarization. Then, we reconstruct the states within the same class to make it spatially uniform. These uniformly polarized pure states, $|n\rangle$'s, are eigenstates of h_z . They also form a complete-orthogonal basis of the nuclear spin system. A formal expression of $|n\rangle$ is³³

$$|n\rangle = \sum_{m_1 \dots m_N} \alpha_{m_1 \dots m_N}^n \otimes_{j=1}^N |I, m_j\rangle. \quad (14)$$

Here, $|I, m_j\rangle$ denotes the eigenstate of the z component of the j th nuclear spin I_{jz} with the eigenvalue $\hbar m_j$. N denotes the number of the nuclei. The equation of motion for the case with initial nuclear spin state $\rho_1^{ns}(0) = |n\rangle\langle n|$ is given by³³

$$\begin{aligned} \frac{d\rho^e(t)}{dt} &= -\frac{i}{\hbar} \{ H_e + \text{Tr}_{ns} \\ &\times [H_{eI} \rho_1^{ns}(0)], \rho^e(t) \} - \frac{1}{\hbar^2} \int_0^t d\tau \text{Tr}_{ns} \{ [H_{eI2}, U_0^{eI}(\tau) \\ &\times [H_{eI2}, \rho^e(t-\tau) \otimes \rho_1^{ns}(0)] U_0^{eI\dagger}(\tau)] \}. \quad (15) \end{aligned}$$

As in traditional projection operator technique, the dynamics

of the nuclear spin subsystem is incorporated self-consistently in the last term.^{33,56} Here, Tr_{ns} is the trace over nuclear spin degrees of freedom. $U_0^{el}(\tau) = \exp[-i\tau(H_e + H_I + H_{el1})]$. The Overhauser field is given by $\mathbf{h} = \sum_j A v_0 \mathbf{I}_j \delta(\mathbf{r} - \mathbf{R}_j)$, where the constants A and v_0 are given later. \mathbf{I}_j and \mathbf{R}_j are the spin and position of the j th nucleus, respectively. As mentioned above, the initial state of the nuclear spin bath is chosen to be a state with equal probability of each state; therefore, $\rho^{ns}(0) = \sum_n 1/N_w |n\rangle\langle n|$, with $N_w = \sum_n 1$ being the number of states of the basis $\{|n\rangle\}$. To quantify the irreversible decay, we calculate the time evolution of $S_+^{(n)}$ for every case with initial nuclear spin state $|n\rangle$. We then sum over n and obtain

$$\| \langle S_+ \rangle_t \| = \sum_n | \langle S_+^{(n)} \rangle_t |. \quad (16)$$

It is noted that the summation is performed after the absolute value of $\langle S_+^{(n)} \rangle_t$. Therefore, the destructive interference due to the difference in precession frequency ω_{zn} , which originates from the longitudinal part of the hyperfine interaction (H_{el1}), is removed. We thus use the $1/e$ decay of the envelope of $\| \langle S_+ \rangle_t \|$ to describe the irreversible spin dephasing time T_2 . Similar description has been used in the irreversible spin dephasing in semiconductor quantum wells⁶² and the irreversible interband optical dephasing in semiconductors.^{63,64}

Expanding Eq. (15) in the basis of $\{|n\rangle\}$, one obtains

$$\begin{aligned} \frac{d}{dt} \rho_{\ell_1 \ell_2}^e = & -\frac{i}{\hbar} \sum_{\ell_3} \{ (\epsilon_{\ell_1} \delta_{\ell_1 \ell_3} + H_{n\ell_1; n\ell_3}^{eI1}) \rho_{\ell_3 \ell_2}^e - \rho_{\ell_1 \ell_3}^e (\epsilon_{\ell_3} \delta_{\ell_3 \ell_2} \\ & + H_{n\ell_3; n\ell_2}^{eI1}) \} \\ & - \left\{ \frac{1}{\hbar^2} \int_0^t d\tau \sum_{n_1} \sum_{\ell_3 \ell_4} [H_{n\ell_1; n_1 \ell_3}^{eI2} H_{n_1 \ell_3; n\ell_4}^{eI2} \rho_{\ell_4 \ell_2}^e(t-\tau) \right. \\ & \left. - H_{n\ell_1; n_1 \ell_3}^{eI2} \rho_{\ell_3 \ell_4}^e(t-\tau) H_{n_1 \ell_4; n\ell_2}^{eI2}] + \text{H.c.} \right\}. \quad (17) \end{aligned}$$

Here, $H_{n\ell_1; n_1 \ell_3}^{eI2} = \langle n\ell_1 | H_{el2} | n_1 \ell_3 \rangle$ and

$$H_{n\ell_1; n_1 \ell_3}^{I2} = \langle n\ell_1 | H_{el2}(-\tau) | n_1 \ell_3 \rangle.$$

For simplicity, we neglect the terms concerning different orbital wave functions which are much smaller. For small spin mixing, assuming an equilibrium distribution in the orbital degree of freedom, under rotating wave approximation, and trace over the orbital degree of freedom, we finally arrive at

$$\begin{aligned} \frac{d}{dt} \langle S_+^{(n)} \rangle_t = & i\omega_{zn} \langle S_+^{(n)} \rangle_t - \frac{1}{\hbar^2} \int_0^t d\tau \left\{ \frac{1}{4} \sum_{kn'} f_k([h_+]_{knn'} [h_-]_{kn'n} \right. \\ & \left. + [h_-]_{knn'} [h_+]_{kn'n}) \exp[i\tau(\omega_{kn} - \omega_{kn'})] \right\} \langle S_+^{(n)} \rangle_{t-\tau}. \quad (18) \end{aligned}$$

Here, $\omega_{zn} = \sum_k f_k (E_{zk}/\hbar + \omega_{kn})$ with E_{zk} representing the electron Zeeman splitting of the k th orbital level. $[h_i]_{knn'} = \langle n | \langle k | h_i | k \rangle | n' \rangle$ ($i = \pm, z$). $\omega_{kn} = [h_z]_{knn} + \epsilon_{nz}$ with ϵ_{nz} denoting the nuclear Zeeman splitting which is very small and can be

neglected. By solving the above equation, we obtain $| \langle S_+^{(n)} \rangle_t |$ for a given $|n\rangle$. We then sum over n and determine the irreversible spin dephasing time T_2 as the $1/e$ decay of the envelope of $\| \langle S_+ \rangle_t \|$. By noting that only the polarization of nuclear spin state $|n\rangle$ determines the evolution of $| \langle S_+^{(n)} \rangle_t |$, the summation over n is then reduced to the summation over polarization which becomes an integration for large N . This integration can be handled numerically.

In the limiting case of zero SOC and very low temperature, only the lowest two Zeeman sublevels are concerned. The equation for $\langle S_+ \rangle_t$ with initial nuclear spin state $\rho_1^{ns}(0) = |n\rangle\langle n|$ reduces to

$$\begin{aligned} \frac{d}{dt} \langle S_+ \rangle_t = & i\omega_{zn} \langle S_+ \rangle_t - \frac{1}{\hbar^2} \int_0^t d\tau \left\{ \frac{1}{4} \sum_{n'} ([h_+]_{nn'} [h_-]_{n'n} \right. \\ & \left. + [h_-]_{nn'} [h_+]_{n'n}) \exp[i\tau(\omega_n - \omega_{n'})] \right\} \langle S_+ \rangle_{t-\tau} \\ = & i\omega_z \langle S_+ \rangle_t - \int_0^t d\tau \Sigma(\tau) \langle S_+ \rangle_{t-\tau}. \quad (19) \end{aligned}$$

In this equation, $\omega_{zn} = (g\mu_B B + [h_z]_{nn'})/\hbar$, $[h_\xi]_{nn'} = \langle n | \langle \psi_1 | h_\xi | \psi_1 \rangle | n' \rangle$ ($\xi = \pm, z$ and ψ_1 is the orbital quantum number of the ground state), and $\omega_n = [h_z]_{nn}$. Similar equation has been obtained by Coish and Loss,³³ and later by Deng and Hu³⁵ at a very low temperature such that only the lowest two Zeeman sublevels are considered. Coish and Loss also presented an efficient way to evaluate $\Sigma(\tau)$ in terms of their Laplace transformations, $\Sigma(s) = \int_0^\infty d\tau e^{-s\tau} \Sigma(\tau)$. They gave

$$\Sigma(s) = \frac{1}{4\hbar^2} \sum_{n'} ([h_+]_{nn'} [h_-]_{n'n} + [h_-]_{nn'} [h_+]_{n'n}) / (s - i\delta\omega_{nn'}), \quad (20)$$

with $\delta\omega_{nn'} = \frac{1}{2}(\omega_n - \omega_{n'})$. With the help of this technique, we are able to investigate the spin dephasing due to the hyperfine interaction.

C. Spin decoherence mechanisms

In this subsection, we briefly summarize all the spin decoherence mechanisms. It is noted that the SOC modifies all the mechanisms. This is because the SOC modifies the Zeeman splitting¹⁸ and the spin-resolved eigenstates of the electron Hamiltonian; it hence greatly changes the effect of the electron-BP scattering.¹⁸ These two modifications, especially the modification of the Zeeman splitting, also change the effect of other mechanisms, such as the direct spin-phonon coupling due to the phonon-induced strain, the g -factor fluctuation, the coaction of the electron-phonon interaction, and the hyperfine interaction. In the literature, except for the electron-BP scattering, the effects from the SOC are neglected except for the work by Woods *et al.*¹⁶ in which the spin relaxation time between the two Zeeman sublevels of the lowest electronic state due to the phonon-induced strain is investigated. However, the perturbation method they used does not include the important second-order energy correc-

tion. In our investigation, the effects of the SOC are included in all the mechanisms and we will show that they lead to marked effects in most cases.

1. Spin-orbit coupling together with electron-phonon scattering

As the SOC mixes different spins, the electron-BP scattering can induce spin relaxation and dephasing. The electron-BP coupling is given by

$$H_{ep} = \sum_{\mathbf{q}\eta} M_{\mathbf{q}\eta} (a_{\mathbf{q}\eta} + a_{-\mathbf{q}\eta}^\dagger) e^{i\mathbf{q}\cdot\mathbf{r}}, \quad (21)$$

where $M_{\mathbf{q}\eta}$ is the matrix element of the electron-phonon interaction. In the general form of the electron phonon interaction H_{e-ph} , $\Phi_{\mathbf{q}\eta} = M_{\mathbf{q}\eta}$ and $X_{\mathbf{q}\eta}(\mathbf{r}, \boldsymbol{\sigma}) = e^{i\mathbf{q}\cdot\mathbf{r}}$. $|M_{\mathbf{q}\eta}|^2 = \hbar \Xi^2 q / 2\rho v_{sl} V$ for the electron-BP coupling due to the deformation potential. For the piezoelectric coupling, $|M_{\mathbf{q}\eta}|^2 = (32\hbar \pi^2 e^2 e_{14}^2 / \kappa^2 \rho v_{sl} V) [(3q_x q_y q_z)^2 / q^7]$ for the longitudinal phonon mode and $\sum_{j=1,2} |M_{\mathbf{q}\eta j}|^2 = [32\hbar \pi^2 e^2 e_{14}^2 / (\kappa^2 \rho v_{sl} q^5 V)] \times [q_x^2 q_y^2 + q_y^2 q_z^2 + q_z^2 q_x^2 - (3q_x q_y q_z)^2 / q^2]$ for the two transverse modes. Here, Ξ stands for the acoustic deformation potential, ρ is the GaAs volume density, V is the volume of the lattice, e_{14} is the piezoelectric constant, and κ denotes the static dielectric constant. The acoustic phonon spectra $\omega_{\mathbf{q}l} = v_{sl} q$ for the longitudinal mode and $\omega_{\mathbf{q}pt} = v_{st} q$ for the transverse mode with v_{sl} and v_{st} representing the corresponding sound velocities.

Besides the electron-BP scattering, electron also couples to vibrations of the confining potential, i.e., the surface phonons,²⁸

$$\delta V(\mathbf{r}) = - \sum_{\mathbf{q}\eta} \sqrt{\frac{\hbar}{2\rho\omega_{\mathbf{q}\eta} V}} (a_{\mathbf{q}\eta} + a_{-\mathbf{q}\eta}^\dagger) \boldsymbol{\epsilon}_{\mathbf{q}\eta} \cdot \nabla_{\mathbf{r}} V_c(\mathbf{r}), \quad (22)$$

in which $\boldsymbol{\epsilon}_{\mathbf{q}\eta}$ is the polarization vector of a phonon mode with wave-vector \mathbf{q} in branch η . However, this contribution is much smaller than the electron-BP coupling. Compared to the coupling due to the deformation potential, for example, the ratio of the two coupling strengths is $\approx \hbar \omega_0 / \Xi q l_0$, where l_0 is the characteristic length of the quantum dot and $\hbar \omega_0$ is the orbital level splitting. The phonon wave vector q is determined by the energy difference between the final and initial states of the transition. Typically, for phonon transitions between Zeeman sublevels and different orbital levels, $q l_0$ ranges from 0.1 to 10. Bearing in mind that $\hbar \omega_0$ is about 1 meV while $\Xi = 7$ eV in GaAs, $\hbar \omega_0 / \Xi q l_0$ is about 10^{-3} . The piezoelectric coupling is of the same order as the deformation potential. Therefore, spin decoherence due to the electron-surface-phonon coupling is negligible.

2. Direct spin-phonon coupling due to phonon-induced strain

The direct spin-phonon coupling due to the phonon-induced strain is given by⁶⁵

$$H_{strain} = \frac{1}{2} \mathbf{h}^s(\mathbf{p}) \cdot \boldsymbol{\sigma}, \quad (23)$$

where $h_x^s = -Dp_x(\epsilon_{yy} - \epsilon_{zz})$, $h_y^s = -Dp_y(\epsilon_{zz} - \epsilon_{xx})$, and $h_z^s = -Dp_z(\epsilon_{xx} - \epsilon_{yy})$ with $\mathbf{p} = (p_x, p_y, p_z) = -i\hbar \nabla$ and D being

the material strain constant. ϵ_{ij} ($i, j = x, y, z$) can be expressed by the phonon creation and annihilation operators

$$\epsilon_{ij} = \sum_{\mathbf{q}\eta=l,t_1,t_2} \frac{i}{2} \sqrt{\frac{\hbar}{2\rho\omega_{\mathbf{q}\eta} V}} (a_{\mathbf{q},\eta} + a_{-\mathbf{q},\eta}^\dagger) (\xi_{i\eta} q_j + \xi_{j\eta} q_i) e^{i\mathbf{q}\cdot\mathbf{r}}, \quad (24)$$

in which $\xi_{il} = q_i / q$ for the longitudinal phonon mode and

$$(\xi_{xt_1}, \xi_{yt_1}, \xi_{zt_1}) = (q_x q_z, q_y q_z, -q_{\parallel}^2) / q q_{\parallel},$$

$(\xi_{xt_2}, \xi_{yt_2}, \xi_{zt_2}) = (q_y, -q_x, 0) / q_{\parallel}$ for the two transverse phonon modes with $q_{\parallel} = \sqrt{q_x^2 + q_y^2}$. Therefore, in the general form of electron-phonon interaction H_{e-ph} , $\Phi_{\mathbf{q}\eta} = -iD \sqrt{\hbar} / (32\rho\omega_{\mathbf{q}\eta} V)$ and $X_{\mathbf{q}\eta}(\mathbf{r}, \boldsymbol{\sigma}) = \sum_{ijk} \epsilon_{ijk} (\xi_{j\eta} q_j - \xi_{k\eta} q_k) p_i e^{i\mathbf{q}\cdot\mathbf{r}} \sigma_i$ with ϵ_{ijk} denoting the Levi-Civita tensor.

3. g-factor fluctuation

The spin-lattice interaction via phonon modulation of the g factor is given by¹²

$$H_g = \frac{\hbar}{2} \sum_{ijkl=x,y,z} A_{ijkl} \mu_B B_i \sigma_j \epsilon_{kl}, \quad (25)$$

where ϵ_{kl} is given in Eq. (24) and A_{ijkl} is a tensor determined by the material. Therefore in H_{e-ph} , $\Phi_{\mathbf{q}\eta} = i \sqrt{\hbar} / (32\rho\omega_{\mathbf{q}\eta} V)$ and $X_{\mathbf{q}\eta}(\mathbf{r}, \boldsymbol{\sigma}) = \sum_{i,j,k,l} A_{i,j,k,l} \mu_B B_i (\xi_{k\eta} q_k - \xi_{l\eta} q_l) \sigma_j e^{i\mathbf{q}\cdot\mathbf{r}}$. Due to the axial symmetry with respect to the z axis and keeping in mind that the external magnetic field is along the z direction, the only finite element of H_g is $H_g = [(A_{33} - A_{31}) \epsilon_{zz} + A_{31} \sum_i \epsilon_{ii}] \hbar \mu_B B \sigma_z / 2$ with $A_{33} = A_{zzzz}$, $A_{31} = A_{zzxx}$, and $A_{66} = A_{xyxy}$. $A_{33} + 2A_{31} = 0$.⁴⁵

4. Hyperfine interaction

The hyperfine interaction between the electron and nuclear spins is⁶⁶

$$H_{el}(\mathbf{r}) = \sum_j A v_0 \mathbf{S} \cdot \mathbf{I}_j \delta(\mathbf{r} - \mathbf{R}_j), \quad (26)$$

where $\mathbf{S} = \hbar \boldsymbol{\sigma} / 2$ and \mathbf{I}_j are the electron and nucleus spins, respectively, $v_0 = a_0^3$ is the volume of the unit cell with a_0 representing the crystal lattice parameter, and $\mathbf{r}(\mathbf{R}_j)$ denotes the position of the electron (the j th nucleus). $A = 4\mu_0 \mu_B \mu_I / (3Iv_0)$ is the hyperfine coupling constant with μ_0 , μ_B , and μ_I representing the permeability of vacuum, the Bohr magneton, and the nuclear magneton separately.

As the Zeeman splitting of the electron is much larger (3 orders of magnitude larger) than that of the nucleus spin, to conserve the energy for the spin relaxation processes, there must be phonon-assisted transitions when considering the spin-flip processes. Taking into account directly the BP induced motion of nuclei spin of the lattice leads to a new spin relaxation mechanism,²⁸

$$V_{el-ph}^{(1)}(\mathbf{r}) = - \sum_j A v_0 \mathbf{S} \cdot \mathbf{I}_j [\mathbf{u}(\mathbf{R}_j) \cdot \nabla_{\mathbf{r}}] \delta(\mathbf{r} - \mathbf{R}_j), \quad (27)$$

where $\mathbf{u}(\mathbf{R}_j^0) = \sum_{\mathbf{q}\eta} \sqrt{\hbar} / (2\rho\omega_{\mathbf{q}\eta} v_0) (a_{\mathbf{q}\eta} + a_{-\mathbf{q}\eta}^\dagger) \boldsymbol{\epsilon}_{\mathbf{q}\eta} e^{i\mathbf{q}\cdot\mathbf{R}_j^0}$ is the lattice displacement vector. Therefore, using the notation of

Eq. (10), $\Phi = \sqrt{\hbar/(2\rho V\omega_{q\eta})}$ and $X_{q\eta} = \sum_j Av_0 \mathbf{S} \cdot \mathbf{I}_j \nabla_{\mathbf{r}} \delta(\mathbf{r} - \mathbf{R}_j)$. The second-order process of the surface phonon and the BP together with the hyperfine interaction also leads to spin relaxation,

$$V_{el-ph}^{(2)}(\mathbf{r}) = |\ell_2\rangle \left\{ \sum_{m \neq \ell_1} \frac{\langle \ell_2 | \delta V_c(\mathbf{r}) | m \rangle \langle m | H_{el}(\mathbf{r}) | \ell_1 \rangle}{\varepsilon_{\ell_1} - \varepsilon_m} + \sum_{m \neq \ell_2} \frac{\langle \ell_2 | H_{el}(\mathbf{r}) | m \rangle \langle m | \delta V_c(\mathbf{r}) | \ell_1 \rangle}{\varepsilon_{\ell_2} - \varepsilon_m} \right\} \langle \ell_1 |, \quad (28)$$

and

$$V_{el-ph}^{(3)} = |\ell_2\rangle \left\{ \sum_{m \neq \ell_1} \frac{\langle \ell_2 | H_{ep} | m \rangle \langle m | H_{el}(\mathbf{r}) | \ell_1 \rangle}{\varepsilon_{\ell_1} - \varepsilon_m} + \sum_{m \neq \ell_2} \frac{\langle \ell_2 | H_{el}(\mathbf{r}) | m \rangle \langle m | H_{ep} | \ell_1 \rangle}{\varepsilon_{\ell_2} - \varepsilon_m} \right\} \langle \ell_1 |, \quad (29)$$

in which $|\ell_1\rangle$ and $|\ell_2\rangle$ are the eigenstates of H_e . By using the notations in H_{e-ph} , $\Phi_{q\eta} = \frac{i}{\hbar} \sqrt{\hbar/(2\rho\omega_{q\eta}v_0)}$ and

$$X_{q\eta} = |\ell_2\rangle \boldsymbol{\epsilon}_{q\eta} \cdot \left\{ \sum_{m \neq \ell_1} \frac{1}{\varepsilon_{\ell_1} - \varepsilon_m} \langle \ell_2 | [H_e, \mathbf{P}] | m \rangle \times \sum_j Av_0 \langle m | \mathbf{S} \cdot \mathbf{I}_j \delta(\mathbf{r} - \mathbf{R}_j) | \ell_1 \rangle + \sum_{m \neq \ell_2} \frac{1}{\varepsilon_{\ell_2} - \varepsilon_m} \langle m | [H_e, \mathbf{P}] | \ell_1 \rangle \sum_j Av_0 \langle \ell_2 | \mathbf{S} \cdot \mathbf{I}_j \delta(\mathbf{r} - \mathbf{R}_j) | m \rangle \right\} \langle \ell_1 | \quad (30)$$

for $V_{el-ph}^{(2)}$. Similarly, $\Phi_{q\eta} = M_{q\eta}$ and

$$X_{q\eta} = |\ell_2\rangle \left\{ \sum_{m \neq \ell_1} \frac{\langle \ell_2 | e^{i\mathbf{q}\cdot\mathbf{r}} | m \rangle}{\varepsilon_{\ell_1} - \varepsilon_m} \sum_j Av_0 \langle m | \mathbf{S} \cdot \mathbf{I}_j \delta(\mathbf{r} - \mathbf{R}_j) | \ell_1 \rangle + \sum_{m \neq \ell_2} \frac{1}{\varepsilon_{\ell_2} - \varepsilon_m} \langle m | e^{i\mathbf{q}\cdot\mathbf{r}} | \ell_1 \rangle \sum_j Av_0 \langle \ell_2 | \mathbf{S} \cdot \mathbf{I}_j \delta(\mathbf{r} - \mathbf{R}_j) \times | m \rangle \right\} \langle \ell_1 | \quad (31)$$

for $V_{el-ph}^{(3)}$. Again, as the contribution from the surface phonon is much smaller than that of the BP, $V_{el-ph}^{(2)}$ can be neglected. It is noted that the direct spin-phonon coupling due to the phonon-induced strain together with the hyperfine interaction gives a fourth-order scattering and hence induces a spin relaxation (dephasing). The interaction is

$$V_{el-ph}^{(4)} = |\ell_2\rangle \left\{ \sum_{m \neq \ell_1} \frac{\langle \ell_2 | H_{strain}^z | m \rangle \langle m | H_{el}(\mathbf{r}) | \ell_1 \rangle}{\varepsilon_{\ell_1} - \varepsilon_m} + \sum_{m \neq \ell_2} \frac{\langle \ell_2 | H_{el}(\mathbf{r}) | m \rangle \langle m | H_{strain}^z | \ell_1 \rangle}{\varepsilon_{\ell_2} - \varepsilon_m} \right\} \langle \ell_1 |, \quad (32)$$

with $H_{strain}^z = \hbar_s^z \sigma_z / 2$ only changing the electron energy but conserving the spin polarization. It can be written as

$$\frac{1}{2} \hbar_s^z = -\frac{i}{2} D \sum_{q\eta} \sqrt{\frac{\hbar}{2\rho\omega_{q,\eta}V}} (\xi_{y\eta} a_y - \xi_{z\eta} a_z) q_z e^{i\mathbf{q}\cdot\mathbf{r}}. \quad (33)$$

Comparing this to the electron-BP interaction [Eq. (21)], the ratio is $\approx \hbar D q / \Xi$, which is about 10^{-3} . Therefore, the second-order term of the direct spin-phonon coupling due to the phonon-induced strain together with the hyperfine interaction is very small and can be neglected. Also, the coaction of the g -factor fluctuation and the hyperfine interaction is very small compared to that of the electron-BP interaction jointly with the hyperfine interaction as $\mu_B B / \Xi$ is around 10^{-5} when $B = 1$ T. Therefore, it can also be neglected. In the following, we only retain the first and the third order terms $V_{el-ph}^{(1)}$ and $V_{el-ph}^{(3)}$ in calculating the spin relaxation time.

The spin dephasing time induced by the hyperfine interaction can be calculated from the non-Markovian kinetic equation [Eq. (18)], for unpolarized initial nuclear spin state $|n_0\rangle$, resulting in

$$\langle S_+^{(n_0)} \rangle_t \propto \sum_k f_k A^2 v_0^2 \int d\mathbf{r} |\psi_k(\mathbf{r})|^4 \cos\left(\frac{Av_0}{2} |\psi_k(\mathbf{r})|^2 t\right), \quad (34)$$

where f_k is the thermoequilibrium distribution of the orbital degree of freedom. When only the lowest two Zeeman sub-levels are considered, assuming a simple form of the wave function, $|\Psi(\mathbf{r})|^2 = \frac{1}{a_z d_{\parallel}^2 \pi} \exp(-r_{\parallel}^2 / d_{\parallel}^2)$ with $d_{\parallel}(a_z)$ representing the QD diameter (quantum well width) and $r_{\parallel} = x^2 + y^2$, the integration can be carried out,

$$\langle S_+^{(n_0)} \rangle_t \propto \frac{\cos(t/t_0) - 1}{(t/t_0)^2} + \frac{\sin(t/t_0)}{t/t_0}. \quad (35)$$

Here, $t_0 = (2\pi a_z d_{\parallel}^2) / (Av_0)$ determines the spin dephasing time. Note that t_0 is proportional to the factor $a_z d_{\parallel}^2$, where $a_z(d_{\parallel}^2)$ is the characteristic length (area) of the QD along the z direction (in the quantum well plane). By solving Eq. (18) for various n and summing over n , we obtain $\|\langle S_+ \rangle_t\| = \sum_n |\langle S_+^{(n)} \rangle_t|$. We then define the time when the envelop of $\|\langle S_+ \rangle_t\|$ decays to $1/e$ of its initial value as the spin dephasing time T_2 . As mentioned above, the hyperfine interaction cannot transfer an energy of the order of the Zeeman splitting; thus, the hyperfine interaction alone cannot lead to any spin relaxation.⁴³

In the above discussion, the nuclear spin dipole-dipole interaction is neglected. Recently, more careful examinations based on the quantum cluster expansion method or pair correlation method have been performed.^{41-43,47} In these works, the nuclear spin dipole-dipole interaction is also included. This interaction together with the hyperfine mediated nuclear spin-spin interaction is the origin of the fluctuation of the nuclear spin bath. To the lowest order, the fluctuation is dominated by nuclear spin pair flips.^{41-43,47} This fluctuation provides the source of the electron spin dephasing, as the electron spin is coupled to the nuclear spin system via hyperfine interaction. Our method used here includes only the hyperfine interaction to the second order in scattering. However, it is found that the dipole-dipole-interaction-induced spin dephasing is much weaker than the hyperfine interaction

TABLE I. Parameters used in the calculation.

ρ	$5.3 \times 10^3 \text{ kg/m}^3$	κ	12.9
v_{st}	$2.48 \times 10^3 \text{ m/s}$	g	-0.44
v_{sl}	$5.29 \times 10^3 \text{ m/s}$	Ξ	7.0 eV
e_{14}	$1.41 \times 10^9 \text{ V/m}$	m^*	0.067 m_0
A	90 μeV	A_{33}	19.6
γ_0	27.5 $\text{\AA}^3 \text{ eV}$	I	$\frac{3}{2}$
D	$1.59 \times 10^4 \text{ m/s}$	a_0	5.6534 \AA

for a QD with $a=2.8 \text{ nm}$ and $d_0=27 \text{ nm}$ until the parallel magnetic field is larger than $\sim 20 \text{ T}$.⁴² Therefore, for the situation in this paper, the nuclear dipole-dipole-interaction-induced spin dephasing can be ignored.⁶⁷

III. SPIN DECOHERENCE DUE TO VARIOUS MECHANISMS

Following the equation-of-motion approach developed in Sec. II, we perform a numerical calculation of the spin relaxation and dephasing times in GaAs QDs. Two magnetic field configurations are considered, i.e., the magnetic fields perpendicular and parallel to the well plane (along the x axis). The temperature is taken to be $T=4 \text{ K}$ unless otherwise specified. For all the cases we considered in this paper, the orbital level splitting is larger than an energy corresponding to 40 K. Therefore, the lowest Zeeman sub-levels are mainly responsible for the spin decoherence. When calculating T_1 , the initial distribution is taken to be in the spin majority down state of the eigenstate of the Hamiltonian H_e with a Maxwell-Boltzmann distribution $f_k=C \exp[-\epsilon_k/(k_B T)]$ for different orbital levels (C is the normalization constant). For the calculation of T_2 , we assign the same distribution between different orbital levels but with a superposition of the two spin states within the same orbital level. The parameters used in the calculation are listed in Table I.^{8,68,69}

A. Spin relaxation time T_1

We now study the spin relaxation time and show how it changes with the well width a , the magnetic field B , and the effective diameter $d_0=\sqrt{\hbar \pi/m^* \omega_0}$. We also compare the relative contributions from each relaxation mechanism.

1. Well width dependence

In Figs. 1(a) and 1(b), the spin relaxation times induced by different mechanisms are plotted as a function of the width of the quantum well in which the QD is confined for perpendicular magnetic field $B_\perp=0.5 \text{ T}$ and parallel magnetic field $B_\parallel=0.5 \text{ T}$, respectively. We first concentrate on the perpendicular-magnetic-field case. In Fig. 1(a), the calculation indicates that the spin relaxation due to each mechanism decreases with the increase of well width. Particularly, the electron-BP scattering mechanism decreases much faster than the other mechanisms. It is indicated in the figures that when the well width is small (smaller than 7 nm in the

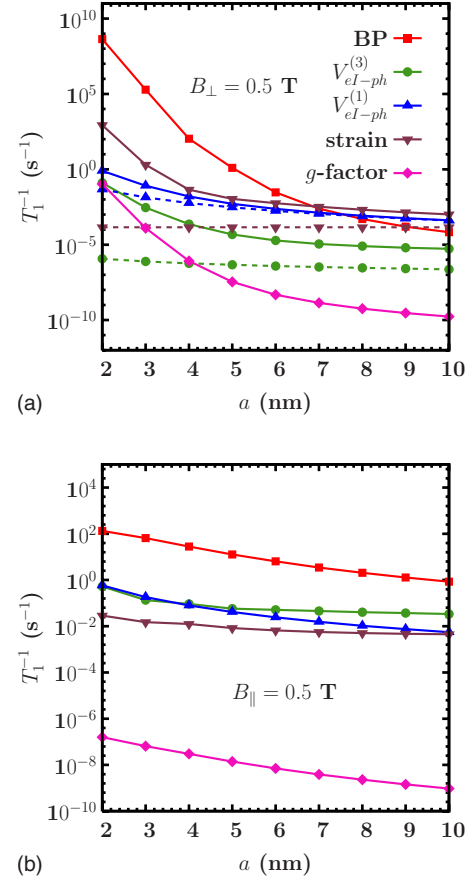


FIG. 1. (Color online) T_1^{-1} induced by different mechanisms vs the well width for (a) perpendicular magnetic field $B_\perp=0.5 \text{ T}$ with (solid curves) and without (dashed curves) the SOC and (b) parallel magnetic field $B_\parallel=0.5 \text{ T}$ with the SOC. The effective diameter $d_0=20 \text{ nm}$ and temperature $T=4 \text{ K}$. Curves with (■)— T_1^{-1} induced by the electron-BP scattering together with the SOC. Curves with (●)— T_1^{-1} induced by the second-order process of the hyperfine interaction together with the BP ($V_{el-ph}^{(3)}$). Curves with (▲)— T_1^{-1} induced by the first-order process of the hyperfine interaction together with the BP ($V_{el-ph}^{(1)}$). Curves with (▼)— T_1^{-1} induced by the direct spin-phonon coupling due to phonon-induced strain. Curves with (◆)— T_1^{-1} induced by the g -factor fluctuation.

present case), the spin relaxation time is determined by the electron-BP scattering together with the SOC. However, for wider well widths, the direct spin-phonon coupling due to phonon-induced strain and the first-order process of hyperfine interaction combined with the electron-BP scattering becomes more important. The decrease of spin relaxation due to each mechanism is mainly caused by the decrease of the SOC which is proportional to a^{-2} . The SOC has two effects which are crucial. First, in the second-order perturbation the SOC contributes a finite correction to the Zeeman splitting which determines the absorbed (emitted) phonon frequency and wave vector.¹⁸ Second, it leads to spin mixing. The decrease of the SOC thus leads to the decrease of Zeeman splitting and spin mixing. The former leads to small phonon wave vector and small phonon absorption (emission) efficiency.¹⁸ Therefore, the electron-BP mechanism decreases rapidly with increasing a . On the other hand, the other two

largest mechanisms can flip spin without the help of the SOC. The spin relaxations due to these two mechanisms decrease in a relatively mild way. It is further confirmed that without SOC, they decrease in a much milder way with increasing a (dashed curves in Fig. 1). It is also noted that the spin relaxation rate due to the g -factor fluctuation is at least 6 orders of magnitude smaller than that due to the leading spin decoherence mechanisms and can therefore be neglected.

It is noted that in the calculation, the SOC is always included as it has large effect on the eigenenergy and eigenwave-function of the electron.¹⁸ We also show the spin relaxation times induced by the hyperfine interactions ($V_{el-ph}^{(1)}$ and $V_{el-ph}^{(3)}$) and the direct spin-phonon coupling due to the phonon-induced strain but without the SOC as in the literature.^{27,28,45} It can be seen clearly that the spin relaxation that includes the SOC is *much* larger than that without the SOC. For example, the spin relaxation induced by the second-order process of the hyperfine interaction together with the BP ($V_{el-ph}^{(3)}$) is at least 1 order of magnitude larger when the SOC is included than that when the SOC is neglected. This is because when the SOC is neglected, $\langle m|H_{el}(\mathbf{r})|\ell_1\rangle$ and $\langle \ell_2|H_{el}(\mathbf{r})|m\rangle$ in Eq. (29) are small as the matrix elements of $H_{el}(\mathbf{r})$ between different orbital energy levels are very small. However, when the SOC is taken into account, the spin-up and -down levels with different orbital quantum numbers are mixed and therefore $|\ell\rangle$ and $|m\rangle$ include the components with the same orbital quantum number. Consequently, the matrix elements of $\langle m|H_{el}(\mathbf{r})|\ell_1\rangle$ and $\langle \ell_2|H_{el}(\mathbf{r})|m\rangle$ become much larger. Therefore, spin relaxation induced by this mechanism depends crucially on the SOC.

It is emphasized from the above discussion that the SOC should be included in each spin relaxation mechanism. In the following calculations, it is always included unless otherwise specified. In particular, in reference to the mechanism of electron-BP interaction, we always consider it together with the SOC.

We further discuss the parallel-magnetic-field case. In Fig. 1(b), the spin relaxation times due to different mechanisms are plotted as a function of the quantum well width for same parameters as Fig. 1(a) but with a parallel magnetic field $B_{\parallel}=0.5$ T. It is noted that the spin relaxation rate due to each mechanism becomes much smaller for small a compared with the perpendicular case. Another feature is that the spin relaxation due to each mechanism decreases in a much slower rate with increasing a . The electron-BP mechanism is dominant even at $a=10$ nm but decreases faster than other mechanisms with a . It is expected to be less effective than the $V_{el-ph}^{(3)}$ mechanism or $V_{el-ph}^{(1)}$ mechanism or the direct spin-phonon coupling due to phonon-induced strain mechanism for large enough a . The g -factor fluctuation mechanism is negligible again. These features can be explained as follows. For parallel magnetic field, the contribution of the SOC to Zeeman splitting is much less than in the perpendicular-magnetic-field geometry.²¹ Moreover, this contribution is *negative* which makes the Zeeman splitting smaller.²¹ Therefore, the phonon absorption (emission) efficiency becomes much smaller for small a , i.e., large SOC. When a increases, the Zeeman splitting increases. However, the spin mixing

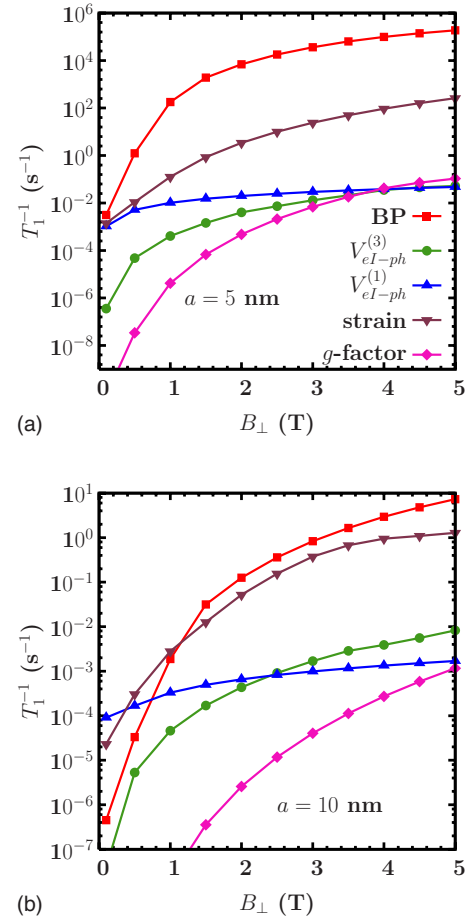


FIG. 2. (Color online) T_1^{-1} induced by different mechanisms vs the perpendicular magnetic field B_{\perp} for $d_0=20$ nm and (a) $a=5$ nm and (b) 10 nm. $T=4$ K. Curves with (■)— T_1^{-1} induced by the electron-BP scattering. Curves with (●)— T_1^{-1} induced by the second-order process of the hyperfine interaction together with the BP ($V_{el-ph}^{(3)}$). Curves with (▲)— T_1^{-1} induced by the first-order process of the hyperfine interaction together with the BP ($V_{el-ph}^{(1)}$). Curves with (▼)— T_1^{-1} induced by the direct spin-phonon coupling due to phonon-induced strain. Curves with (◆)— T_1^{-1} induced by the g -factor fluctuation.

decreases. The former effect is weak and only cancels part of the latter; thus, the spin relaxation due to each mechanism decreases slowly with a .

2. Magnetic field dependence

We first study the perpendicular-magnetic-field case. The magnetic field dependence of T_1 for two different well widths is shown in Figs. 2(a) and 2(b). In the calculation, $d_0=20$ nm. It can be seen that the effect of each mechanism increases with the magnetic field. Particularly, the electron-BP mechanism increases much faster than other ones and becomes dominant at high magnetic fields. For small well width [5 nm in Fig. 2(a)], the spin relaxation induced by the electron-BP scattering is dominant except at very low magnetic fields (0.1 T in the figure) where contributions from the first-order process of hyperfine interaction together with the electron-BP scattering and the direct spin-

phonon coupling due to phonon-induced strain also contribute. It is interesting to see that when a is increased to 10 nm, the electron-BP scattering is the largest spin relaxation mechanism only at high magnetic fields (>1.1 T). For $0.4 \text{ T} < B_{\perp} < 1.1 \text{ T}$ ($B_{\perp} < 0.4 \text{ T}$), the direct spin-phonon coupling due to the phonon-induced strain (the first-order hyperfine interaction together with the BP) becomes the largest relaxation mechanism. It is also noted that there is no single mechanism which dominates the whole spin relaxation. Two or three mechanisms are jointly responsible for the spin relaxation. It is indicated that the spin relaxations induced by different mechanisms all increase with B_{\perp} . This can be understood from a perturbation theory: when the magnetic field is small, the spin relaxation between two Zeeman split states for each mechanism is proportional to $\bar{n}(\Delta E) \times (\Delta E)^m$ (ΔE is the Zeeman splitting) with $m=7$ for electron-BP scattering due to the deformation potential^{18,25} and for the second-order process of the hyperfine interaction together with the electron-BP scattering due to the deformation potential $V_{el-ph}^{(3)}$,²⁷ $m=5$ for electron-BP scattering due to the piezoelectric coupling^{15,18,25} and for the second-order process of the hyperfine interaction together with the electron-BP scattering due to the piezoelectric coupling $V_{el-ph}^{(3)}$,²⁷ $m=5$ for the direct spin-phonon coupling due to phonon-induced strain,¹⁵ and $m=1$ for the first-order process of the hyperfine interaction together with the BP $V_{el-ph}^{(1)}$. The spin relaxation induced by the g -factor fluctuation is proportional to $\bar{n}(\Delta E)(\Delta E)^5 B_{\perp}^2$. For most of the cases studied, ΔE is smaller than $k_B T$; hence, $\bar{n}(\Delta E) \sim k_B T / \Delta E$ and $\bar{n}(\Delta E)(\Delta E)^m \sim (\Delta E)^{m-1}$. $m > 1$ hold for all mechanisms except the $V_{el-ph}^{(1)}$ mechanism; therefore, the spin relaxation due to these mechanisms increases with increasing B_{\perp} . However, from Eq. (27), one can see that it has a term with $\nabla_{\mathbf{r}}$, which indicates that the effect of this mechanism is proportional to $1/d_0$. As the vector potential of the magnetic field increases the confinement of the QD and gives rise to smaller effective diameter d_0 , this mechanism also increases with the magnetic field in the perpendicular-magnetic-field geometry.

We then study the case with the magnetic field parallel to the quantum well plane. In Fig. 3, the spin relaxation induced by different mechanisms is plotted as a function of the parallel magnetic field B_{\parallel} for two different well widths. In the calculation, $d_0=20$ nm. It can be seen that, similar to the case with perpendicular magnetic field, the effects of most mechanisms increase with the magnetic field. Also, the electron-BP mechanism increases much faster than the other ones and becomes dominant at high magnetic fields. However, without the orbital effect of the magnetic field in the present configuration, the effect of $V_{el-ph}^{(1)}$ changes very little with the magnetic field. For both small [5 nm in Fig. 3(a)] and large [10 nm in Fig. 3(b)] well widths, the electron-BP scattering is dominant except at very low magnetic field (0.1 T in the figure), where the first-order process of the hyperfine interaction together with the electron-BP interaction $V_{el-ph}^{(1)}$ also contributes.

3. Diameter dependence

We now turn to the investigation of the diameter dependence of the spin relaxation. We first concentrate on the

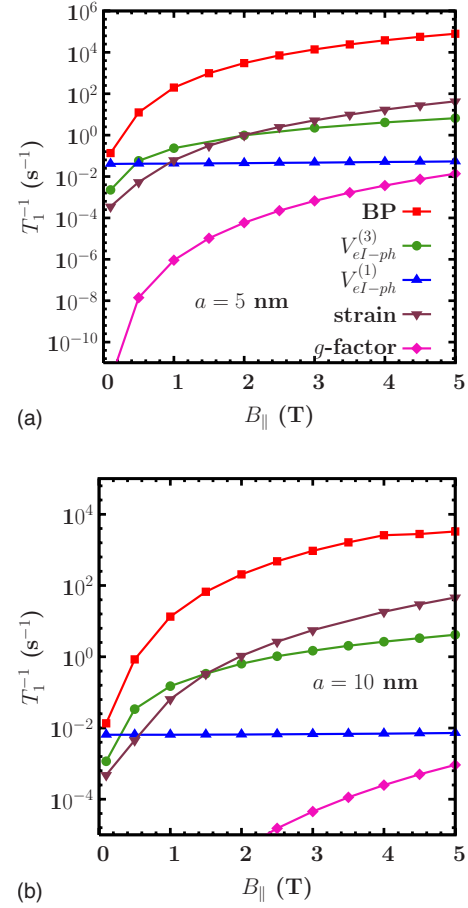


FIG. 3. (Color online) T_1^{-1} induced by different mechanisms vs the parallel magnetic field B_{\parallel} for $d_0=20$ nm and (a) $a=5$ nm and (b) 10 nm. $T=4$ K. Curves with (■)— T_1^{-1} induced by the electron-BP scattering. Curves with (●)— T_1^{-1} induced by the second-order process of the hyperfine interaction together with the BP ($V_{el-ph}^{(3)}$). Curves with (▲)— T_1^{-1} induced by the first-order process of the hyperfine interaction together with the BP ($V_{el-ph}^{(1)}$). Curves with (▼)— T_1^{-1} induced by the direct spin-phonon coupling due to phonon-induced strain. Curves with (◆)— T_1^{-1} induced by the g -factor fluctuation.

perpendicular-magnetic-field geometry. The spin relaxation rate due to each mechanism is shown in Fig. 4(a) for a small well width ($a=5$ nm) and Fig. 4(b) for a large well width ($a=10$ nm), respectively, with a fixed perpendicular magnetic field $B_{\perp}=0.5$ T. In the figure, the spin relaxation rate due to each mechanism except $V_{el-ph}^{(1)}$ increases with the effective diameter. Specifically, the effect of the electron-BP mechanism increases very fast, while the effect of the direct spin-phonon coupling due to the phonon-induced strain mechanism increases very mildly. The $V_{el-ph}^{(1)}$ decreases with d_0 slowly. Other mechanisms are unimportant. The electron-BP mechanism eventually dominates the spin relaxation when the diameter is large enough. The threshold increases from 12 to 26 nm when the well width increases from 5 to 10 nm. For small diameter, the $V_{el-ph}^{(1)}$ and the direct spin-phonon coupling due to the phonon-induced strain mechanism dominate the spin relaxation. The increase (decrease) of the spin relaxation due to these mechanisms can be

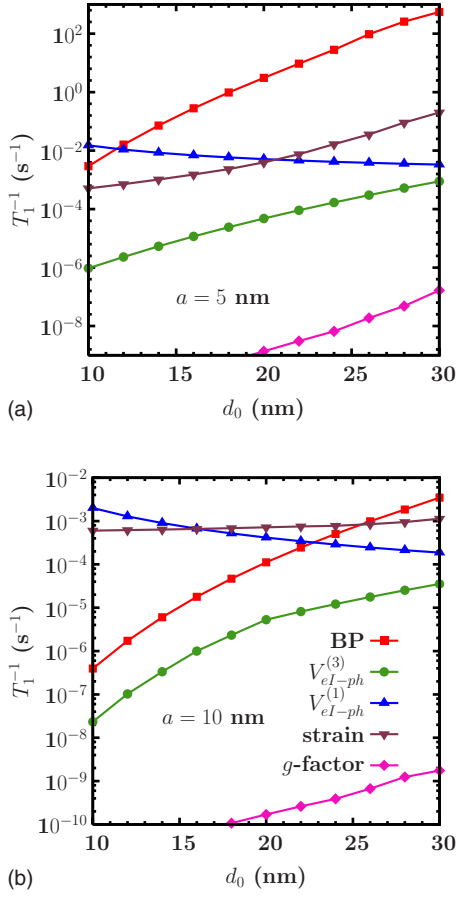


FIG. 4. (Color online) T_1^{-1} induced by different mechanisms vs the effective diameter d_0 for $B_{\perp}=0.5$ T and (a) $a=5$ nm and (b) 10 nm. $T=4$ K. Curves with (■)— T_1^{-1} induced by the electron-BP scattering. Curves with (●)— T_1^{-1} induced by the second-order process of the hyperfine interaction together with the BP ($V_{el-ph}^{(3)}$). Curves with (▲)— T_1^{-1} induced by the first-order process of the hyperfine interaction together with the BP ($V_{el-ph}^{(1)}$). Curves with (▼)— T_1^{-1} induced by the direct spin-phonon coupling due to phonon-induced strain. Curves with (◆)— T_1^{-1} induced by the g-factor fluctuation.

understood from the following. The effect of the SOC on the Zeeman splitting is proportional to d_0^2 for small magnetic field.¹⁸ The increase of d_0 thus leads to an increase of Zeeman splitting; therefore, the efficiency of the phonon absorption (emission) increases. Another effect is that the increase of d_0 will increase the phonon absorption (emission) efficiency due to the increase of the form factor.¹⁸ Thus, the spin relaxation increases. Moreover, the spin mixing is also proportional to d_0 .¹⁸ This leads to a much faster increase of the effect of the electron-BP mechanism and the $V_{el-ph}^{(3)}$ mechanism. However, the spin relaxation due to $V_{el-ph}^{(1)}$ decreases with the diameter. This is because $V_{el-ph}^{(1)}$ contains a term ∇_r [Eq. (27)] which decreases with the increase of d_0 . Physically speaking, the decrease of the effect of $V_{el-ph}^{(1)}$ is due to the fact that the spin mixing due to the hyperfine interaction decreases with the increase of the number of nuclei within the dot N as the random Overhauser field is proportional to $1/\sqrt{N}$. The spin relaxation induced by the g factor is also

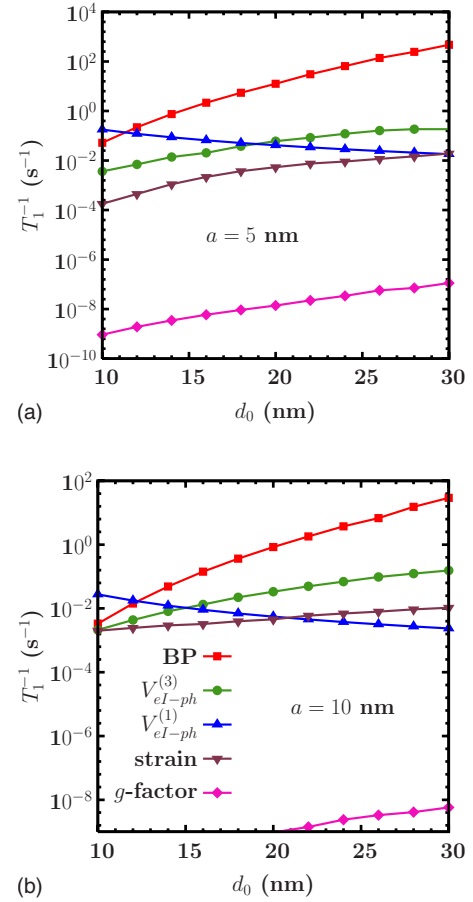


FIG. 5. (Color online) T_1^{-1} induced by different mechanisms vs the effect diameter d_0 with $B_{\parallel}=0.5$ T and (a) $a=5$ nm and (b) 10 nm. $T=4$ K. Curves with (■)— T_1^{-1} induced by the electron-BP scattering. Curves with (●)— T_1^{-1} induced by the second-order process of the hyperfine interaction together with the BP ($V_{el-ph}^{(3)}$). Curves with (▲)— T_1^{-1} induced by the first-order process of the hyperfine interaction together with the BP ($V_{el-ph}^{(1)}$). Curves with (▼)— T_1^{-1} induced by the direct spin-phonon coupling due to phonon-induced strain. Curves with (◆)— T_1^{-1} induced by the g-factor fluctuation.

negligible here for both small and large well widths.

We then turn to the parallel-magnetic-field case. In the calculation, $B_{\parallel}=0.5$ T. The results are shown for both small well width [$a=5$ nm in Fig. 5(a)] and large well width [$a=10$ nm in Fig. 5(b)]. Similar to the perpendicular-magnetic-field case, the effect of every mechanism except the $V_{el-ph}^{(1)}$ mechanism increases with increasing diameter. The effect of the electron-BP mechanism increases fastest and becomes dominant for $d_0 > 12$ nm for both small and large well widths. For $d_0 < 12$ nm for the two cases, the first-order process of the $V_{el-ph}^{(1)}$ mechanism becomes dominant. The effect of the $V_{el-ph}^{(3)}$ mechanism becomes larger than that of the direct spin-phonon coupling due to the phonon-induced strain mechanism. However, these two mechanisms are still unimportant and become more and more unimportant for larger d_0 . Here, the spin relaxation induced by the g factor is negligible.

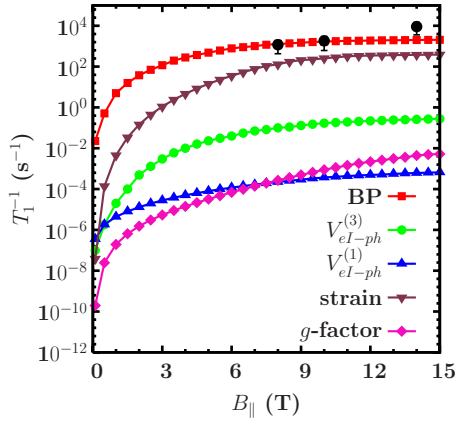


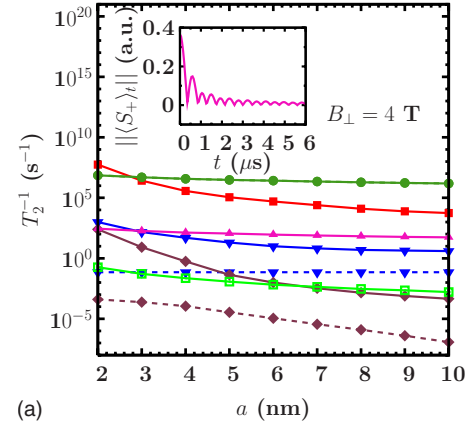
FIG. 6. (Color online) T_1^{-1} induced by different mechanisms vs the parallel magnetic field B_{\parallel} in the [110] direction for $d_0=56$ nm and $a=13$ nm with both the Rashba and Dresselhaus SOC. $T=0$ K. The black dots with error bar are the experimental results in Ref. 7. Curves with (■)— T_1^{-1} induced by the electron-BP scattering. Curves with (●)— T_1^{-1} induced by the second-order process of the hyperfine interaction together with the BP ($V_{el-ph}^{(3)}$). Curves with (▲)— T_1^{-1} induced by the first-order process of the hyperfine interaction together with the BP ($V_{el-ph}^{(1)}$). Curves with (▼)— T_1^{-1} induced by the direct spin-phonon coupling due to phonon-induced strain. Curves with (◆)— T_1^{-1} induced by the g -factor fluctuation.

4. Comparison with experiment

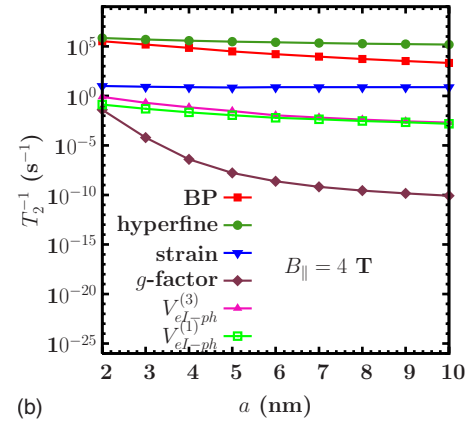
In this subsection, we apply our analysis to the experimental data in Ref. 7. The results are plotted in Fig. 6. We first show that our calculation is in good agreement with the experimental results. Then, we compare contributions from different mechanisms to spin relaxation as a function of the magnetic field. In the calculation, we choose the quantum dot diameter $d_0=56$ nm ($\hbar\omega_0=1.1$ meV as in experiment). The quantum well is taken to be an infinite-depth well with $a=13$ nm. The Dresselhaus SOC parameter $\gamma_0\langle k_z^2 \rangle$ is taken to be 4.5 meV \AA and the Rashba SOC parameter is 3.3 meV \AA . $T=0$ K as $k_B T \ll g\mu_B B$ in the experiment. The magnetic field is applied parallel to the well plane in the [110] direction. The Dresselhaus cubic term is also taken into consideration. All these parameters are the same with (or close to) those used in Ref. 24 in which a calculation based on the electron-BP scattering mechanism agrees well with the experimental results. For this mechanism, we reproduce their results. The spin relaxation time measured by the experiments (black dots with error bar in the figure) almost coincides with the calculated spin relaxation time due to the electron-BP scattering mechanism (curves with ■ in the figure).⁷¹ It is noted from the figure that other mechanisms are unimportant for small magnetic field. However, for large magnetic field, the effect of the direct spin-phonon coupling due to phonon-induced strain becomes comparable to that of the electron-BP mechanism. At $B_{\parallel}=10$ T, the two differs by a factor of ~ 5 .

B. Spin dephasing time T_2

In this subsection, we investigate the spin dephasing time for different well widths, magnetic fields, and QD diameters.



(a)



(b)

FIG. 7. (Color online) T_2^{-1} induced by different mechanisms vs the well width for $d_0=20$ nm. $T=4$ K. (a) $B_{\perp}=4$ T with (solid curves) and without (dashed curves) the SOC and (b) $B_{\parallel}=4$ T only with the SOC. Curve with (■)— T_2^{-1} induced by the electron-BP interaction. Curves with (●)— T_2^{-1} induced by the hyperfine interaction. Curves with (▼)— T_2^{-1} induced by the direct spin-phonon coupling due to phonon-induced strain. Curves with (◆)— T_2^{-1} induced by g -factor fluctuation. (▲)— T_2^{-1} induced by the second-order process of the hyperfine interaction together with the BP ($V_{el-ph}^{(3)}$). Curves with (□)— T_2^{-1} induced by the first-order process of the hyperfine interaction together with the BP ($V_{el-ph}^{(1)}$). The time evolution of $\|\langle S_+ \rangle\|$ induced by the hyperfine interaction with $a=2$ nm is shown in the inset of (a).

As in the previous subsection, the contributions of the different mechanisms to spin dephasing are compared.⁷⁰ To justify the first Born approximation in studying the hyperfine-interaction-induced spin dephasing, we focus mainly on the high magnetic field regime of $B > 3.5$ T. A typical magnetic field is 4 T. We also demonstrate via extrapolation that in the low magnetic field regime, spin dephasing is dominated by the hyperfine interaction.

1. Well width dependence

In Fig. 7, the well width dependence of the spin dephasing induced by different mechanisms is presented under the perpendicular (a) and parallel (b) magnetic fields. In the calculations, $B_{\perp}=4$ T ($B_{\parallel}=4$ T) and $d_0=20$ nm. It can be seen in both figures that the spin dephasing due to each mechanism

decreases with a . Moreover, the spin dephasing due to the electron-BP scattering decreases much faster than that due to the hyperfine interaction. These features can be understood as follows. The spin dephasing due to electron-BP scattering depends crucially on the SOC. As the SOC is proportional to a^{-2} , the spin dephasing decreases fast with a . For the hyperfine interaction, from Eq. (35), one can deduce that the decay rate of $\|\langle S_+ \rangle_t\|$ is mainly determined by the factor $1/(a_z d_{\parallel}^2)$ (here $a_z = a$), which thus decreases with a but in a very mild way. The fast decrease of the electron-BP mechanism makes it eventually unimportant. For the present perpendicular-magnetic-field case the, threshold is around 2 nm. For parallel magnetic field, it is even smaller. A higher temperature may enhance the electron-BP mechanism (see discussion in Sec. V) and make it more important than the hyperfine mechanism. It is noted that other mechanisms contribute very little to the spin dephasing. Thus, in the following discussion, we do not consider these mechanisms. Comparing Figs. 7(a) and 7(b), one finds that a main difference is that the electron-BP mechanism is less effective for the parallel-magnetic-field case. As has been discussed in the previous subsection, the spin mixing and the Zeeman splitting in the parallel field case is smaller than those in the perpendicular field case. Therefore, the electron-BP mechanism is weakened markedly.

Similar to Fig. 1, the SOC is always included in the computation as it has large effect on the eigenenergy and eigenwave-function of the electrons. The spin dephasings calculated without the SOC for the hyperfine interaction, the direct spin-phonon coupling due to phonon-induced strain, and the g -factor fluctuation are also shown in Fig. 7(a) as dashed curves. It can be seen from the figure that for the spin dephasings induced by the direct spin-phonon coupling due to phonon-induced strain and by the g -factor fluctuation, the contributions with the SOC are much larger than those without. This is because when the SOC is included, the fluctuation of the effective field induced by both mechanisms becomes much stronger and more scattering channels are opened. However, what should be emphasized is that the spin dephasings induced by the hyperfine interaction with and without the SOC are nearly the same (the solid and the dashed curves nearly coincide). This is because the change of the wave function $\Psi(\mathbf{r})$ due to the SOC is very small (less than 1% in our condition) and therefore the factor $1/(a_z d_{\parallel}^2)$ is almost unchanged when the SOC is neglected. Thus, the spin dephasing rate is almost unchanged.

In the inset of Fig. 7(a), the time evolution of $\|\langle S_+ \rangle_t\|$ induced by the hyperfine interaction is shown, with $a=2$ nm. It can be seen that $\|\langle S_+ \rangle_t\|$ decays very fast and decreases to less than 10% of its initial value within the first two oscillating periods. Therefore, T_2 is determined by the first two or three periods of $\|\langle S_+ \rangle_t\|$. Thus, the correction of the long-time dynamics due to higher order scattering³³ contributes little to the spin dephasing time. For quantum computation and quantum information processing, the initial, e.g., 1% decay of $\|\langle S_+ \rangle_t\|$ may be more important than the $1/e$ decay.^{42,43} Indeed, the spin dephasing time defined by the exponential fitting of 1% decay is shorter than that defined by the $1/e$ decay. However, the two differs less than five times. For a

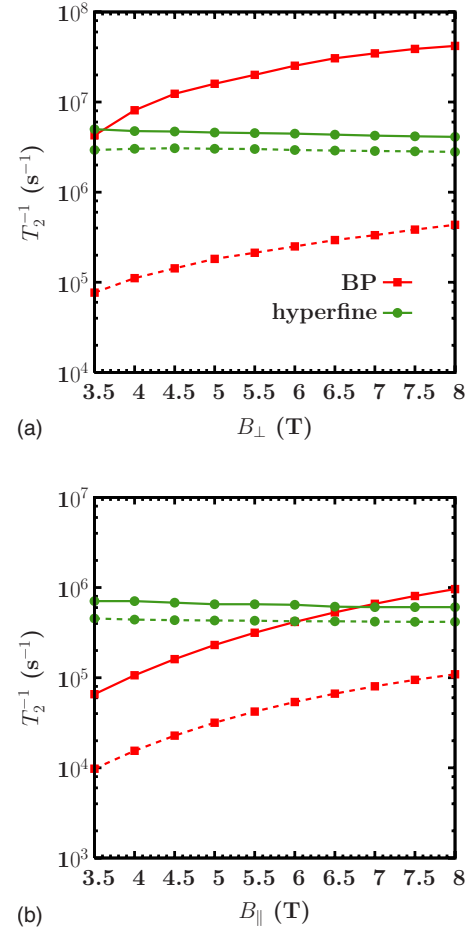


FIG. 8. (Color online) T_2^{-1} induced by the electron-BP scattering and the hyperfine interaction vs (a) the perpendicular magnetic field B_{\perp} and (b) the parallel magnetic field B_{\parallel} for $a=3$ nm (solid curves) and 5 nm (dashed curves). $T=4$ K and $d_0=20$ nm. Curves with (■)— T_2^{-1} induced by the electron-BP interaction. Curves with (●)— T_2^{-1} induced by the hyperfine interaction.

rough comparison of contributions from different mechanisms to spin dephasing where only the order-of-magnitude difference is concerned (see Figs. 7–9), this difference due to the definition does not jeopardize our conclusions.

2. Magnetic field dependence

We then investigate the magnetic field dependence of the spin dephasing induced by the electron-BP scattering and by the hyperfine interaction for two different well widths ($a=3$ nm and $a=5$ nm) with both perpendicular and parallel magnetic fields. From Figs. 8(a) and 8(b), one can see that the spin dephasing due to the electron-BP scattering increases with the magnetic field, whereas that due to the hyperfine interaction decreases with the magnetic field. Thus, the electron-BP mechanism eventually dominates the spin dephasing for high enough magnetic field. The threshold is $B_{\perp}^c=4$ T ($B_{\parallel}^c=7$ T) for $a=3$ nm with perpendicular (parallel) magnetic field. For larger well width, e.g., $a=5$ nm with parallel magnetic field or perpendicular magnetic field, the threshold magnetic fields increase to larger than 8 T. The

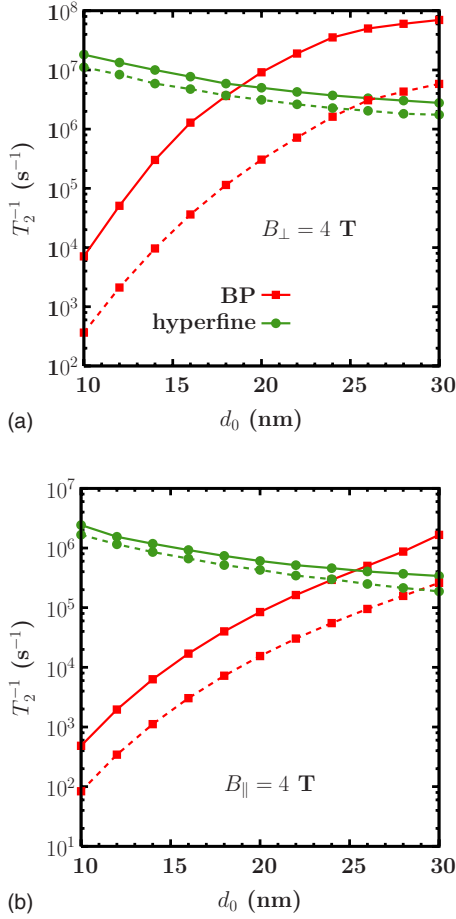


FIG. 9. (Color online) T_2^{-1} induced by the electron-BP scattering and the hyperfine interaction vs the effective diameter d_0 , $T=4$ K. (a) $B_{\perp}=4$ T and (b) $B_{\parallel}=4$ T for $a=3$ nm (solid curves) and 5 nm (dashed curves). Curves with \blacksquare — T_2^{-1} induced by the electron-BP interaction. Curves with \bullet — T_2^{-1} induced by the hyperfine interaction.

different magnetic field dependences above can be understood as follows. Besides spin relaxation, the spin-flip scattering also contributes to spin dephasing.²⁰ As has been demonstrated in Sec. III A, the electron-BP scattering induced spin-flip transition rate increases with the magnetic field. Therefore, the spin dephasing rate increases with the magnetic field also. In contrast, spin dephasing induced by the hyperfine interaction decreases with the magnetic field. This is because when the magnetic field becomes larger, the fluctuation of the effective magnetic field due to the surrounding nuclei becomes insignificant. Therefore, the hyperfine-interaction-induced spin dephasing is reduced. Similar results have been obtained by Deng and Hu.⁴⁴

3. Diameter dependence

In Fig. 9, the spin dephasing times induced by the electron-BP scattering and the hyperfine interaction are plotted as a function of the diameter d_0 for small ($a=3$ nm) and large ($a=5$ nm) well widths. In the calculation, $B_{\perp}=4$ T in Fig. 9(a) and $B_{\parallel}=4$ T in Fig. 9(b). It is noted that the effect of the electron-BP mechanism increases rapidly with d_0 ,

whereas the effect of the hyperfine mechanism decreases slowly. Consequently, the electron-BP mechanism eventually dominates the spin dephasing for large enough d_0 . The threshold is $d_0^c=19$ (27) nm for the $a=3$ (5) nm case with the perpendicular magnetic field and $d_0^c=26$ (30) nm for the $a=3$ (5) nm case under the parallel magnetic field. As has been discussed in Sec. III A, both the effect of the SOC and the efficiency of the phonon absorption (emission) increase with d_0 . Therefore, the spin dephasing due to the electron-BP mechanism increases rapidly with d_0 .^{18,21} The decrease of the effect of the hyperfine interaction is due to the decrease of the factor $1/(a_z d_{\parallel}^2)$ [Eq. (35)] with the diameter d_0 .

IV. SPIN RELAXATION TIMES FROM FERMI GOLDEN RULE AND FROM EQUATION OF MOTION

In this section, we will try to find a proper method to average over the transition rates from the Fermi golden rule, $\tau_{i \rightarrow f}^{-1}$, to give the spin relaxation time T_1 . In the limit of small SOC, we rederive Eq. (1) from the equation of motion. We further show that Eq. (1) fails for large SOC where a full calculation from the equation of motion is needed.

We first rederive Eq. (1) for small SOC from the equation of motion. In QDs, the orbital level splitting is usually much larger than the Zeeman splitting. Each Zeeman sub-level has two states: one with a majority up spin and the other with a majority down spin. We call the former as the “minus state” (as it corresponds to a lower energy), while the latter as the “plus state.” For small SOC, the spin mixing is small. Thus, we neglect the much smaller contribution from the off-diagonal terms of the density matrix to S_z . Therefore, $S_z(t)=\sum_{i\pm} S_z^{i\pm} f_{i\pm}(t)$ where $i\pm$ denotes the plus/minus state of the i th orbital state. For small SOC, the spin relaxation is much slower than the orbital relaxation.^{25,55} This implies that the time to establish equilibrium within the plus/minus states is much smaller than the spin relaxation time. Thus, we can assume an equilibrium (Maxwell-Boltzmann) distribution between the plus/minus states at any time. The distribution function is therefore given by $f_{i\pm}(t)=N_{\pm}(t)\exp(-\varepsilon_{i\pm}/k_B T)/Z_{\pm}$. Here, $N_{\pm}(t)=\sum_i f_{i\pm}(t)$ is the total probability of the plus/minus states with $N_+(t)+N_-(t)=1$ for a single electron in QD and $Z_{\pm}=\sum_i \exp(-\varepsilon_{i\pm}/k_B T)$ is the partition function for the plus/minus state. At equilibrium, $N_{\pm}=N_{\pm}^{eq}$. The equation for $S_z(t)$ is hence

$$\frac{d}{dt} S_z(t) = \frac{d}{dt} [S_z(t) - S_z^{eq}] = \sum_{i\pm} S_z^{i\pm} \exp(-\varepsilon_{i\pm}/k_B T) / Z_{\pm} \frac{d}{dt} \delta N_{\pm}(t), \quad (36)$$

with $\delta N_{\pm}(t) = N_{\pm}(t) - N_{\pm}^{eq}$. As the orbital level splitting is usually much larger than the Zeeman splitting, the factor $\exp(-\varepsilon_{i\pm}/k_B T)/Z_{\pm}$ can be approximated by $\exp(-\varepsilon_{i0}/k_B T)/Z_0$ with $\varepsilon_{i0} = \frac{1}{2}(\varepsilon_{i+} + \varepsilon_{i-})$ and $Z_0 = \sum_i \exp[-\varepsilon_{i0}/k_B T]$. Further using the particle-conservation relation $\sum_{\pm} \delta N_{\pm}(t) = 0$, one has

$$\frac{d}{dt} S_z(t) = \left[\sum_i (S_z^{i+} - S_z^{i-}) \exp(-\varepsilon_{i0}/k_B T) / Z_0 \right] \frac{d}{dt} \delta N_+(t). \quad (37)$$

As $S_z(t) - S_z^{eq} = [\delta N_+(t) / Z_0] \sum_i (S_z^{i+} - S_z^{i-}) \exp(-\varepsilon_{i0}/k_B T)$, one finds that the spin relaxation time is nothing but the relax-

ation time of N_+ . The next step is to derive the equation of $\frac{d}{dt}\delta N_+(t)$, which is given in our previous work,⁴⁹

$$\begin{aligned} \frac{d}{dt}\delta N_+(t) &= \sum_i \frac{d}{dt}\delta f_{i+}(t) = - \sum_{i,f} [\tau_{i+ \rightarrow f-}^{-1} \delta f_{i+}(t) - \tau_{i- \rightarrow f+}^{-1} \delta f_{i-}(t)] \\ &= - \sum_{i,f} [\tau_{i+ \rightarrow f-}^{-1} + \tau_{i- \rightarrow f+}^{-1}] \frac{e^{-\varepsilon_{i0}/k_B T}}{Z_0} \delta N_+(t). \end{aligned} \quad (38)$$

Thus, spin relaxation time is given by

$$\frac{1}{T_1} = \sum_{i,f} (\tau_{i+ \rightarrow f-}^{-1} + \tau_{i- \rightarrow f+}^{-1}) \frac{e^{-\varepsilon_{i0}/k_B T}}{Z_0}. \quad (39)$$

Furthermore, substituting $e^{-\varepsilon_{i0}/k_B T}/Z_0$ by

$f_{i\pm}^0 = \exp(-\varepsilon_{i\pm}/k_B T)/Z_{\pm}$, we have

$$\frac{1}{T_1} = \sum_{i,f} (\tau_{i+ \rightarrow f-}^{-1} f_{i+}^0 + \tau_{i- \rightarrow f+}^{-1} f_{i-}^0). \quad (40)$$

This is exactly Eq. (1).

For large SOC or large spin mixing due to the anticrossing of different spin states,^{19,25} the spin relaxation rate becomes comparable to the orbital relaxation rate. Furthermore, the decay of the off-diagonal term of the density matrix should contribute to the decay of S_z . Therefore, the above analysis does not hold. In this case, it is difficult to obtain such a formula and a full calculation from the equation of motion is needed.

In Fig. 10(a), we show (for $T=12$ K, $a=5$ nm, $B_{\perp}=0.5$ T, $d_0=30$ nm) the spin relaxation times T_1 calculated from the equation-of-motion approach and that obtained from Eq. (40). Here, for simplicity and without loss of generality, we consider only the electron-BP scattering mechanism. The discrepancy of T_1 obtained from the two approaches increases with γ . At $\gamma=10\gamma_0$, the ratio of the two becomes as large as ~ 3 . In Fig. 10(b), we plot the spin relaxation times obtained via the two approaches as a function of temperature for $\gamma=\gamma_0$ with other parameters remaining unchanged. It is noted that the discrepancy of T_1 obtained from the two approaches increases with temperature. For high temperature, the higher levels are involved in the spin dynamics where the SOC becomes larger. At 40 K, the discrepancy is as large as 60%. The ratio increases very slowly for $T < 20$ K where only the lowest two Zeeman sublevels are involved in the dynamics.

V. TEMPERATURE DEPENDENCE OF SPIN RELAXATION TIME T_1 AND SPIN DEPHASING TIME T_2

We first study the relative magnitude of the spin relaxation time T_1 and the spin dephasing time T_2 . We consider a QD with $d_0=30$ nm and $a=5$ nm at $B_{\perp}=4$ T where the largest contribution to both spin relaxation and dephasing comes from the electron-BP scattering [see Figs. 4(a) and 9(a), we have checked that the electron-BP scattering mechanism is dominant throughout the temperature range]. From Fig. 11, one finds that when the temperature is low ($T < 5$ K in the figure), $T_2=2T_1$, which is in agreement with the discussion in

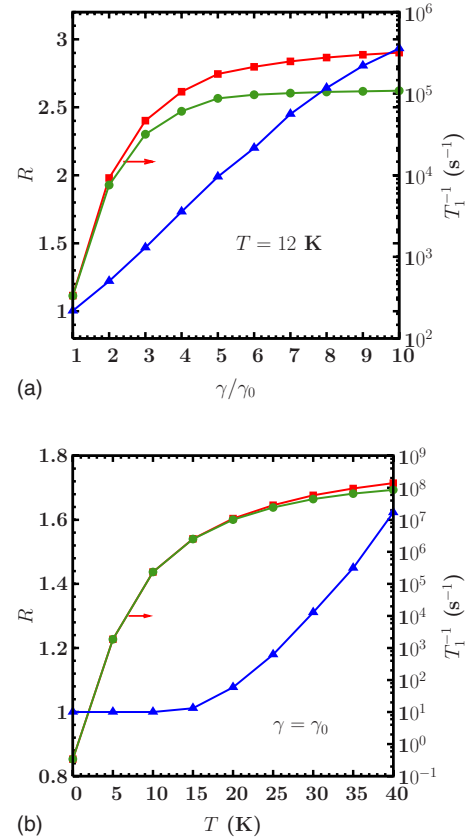


FIG. 10. (Color online) Spin relaxation time T_1 calculated from the equation-of-motion approach (■) vs that obtained from Eq. (1) (●) as a function of (a) the strength of the SOC for $T=12$ K and (b) the temperature for $\gamma=\gamma_0$. The well width $a=5$ nm, perpendicular magnetic field $B_{\perp}=0.5$ T, and QD diameter $d_0=30$ nm. The ratio of the two R is also plotted in the figure. Note that the scale of T_1^{-1} is at the right hand side of the frame.

Ref. 20. However, T_1/T_2 increases very quickly with T and for $T=20$ K, $T_1/T_2 \sim 2 \times 10^2$. This is understood from the fact that when T is low, the electron mostly distributes in the lowest two Zeeman sublevels. For small SOC, Golovach *et*

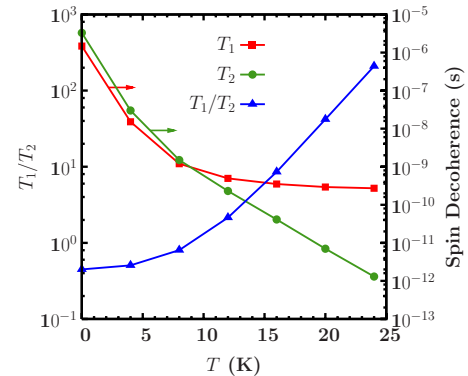
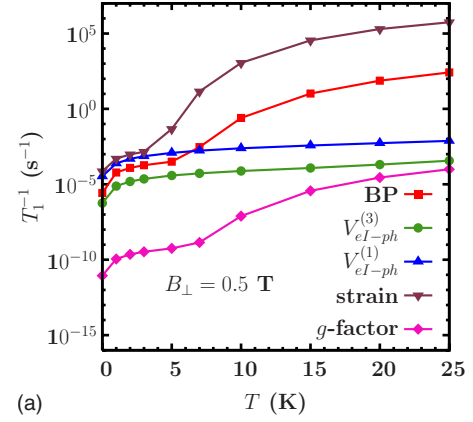


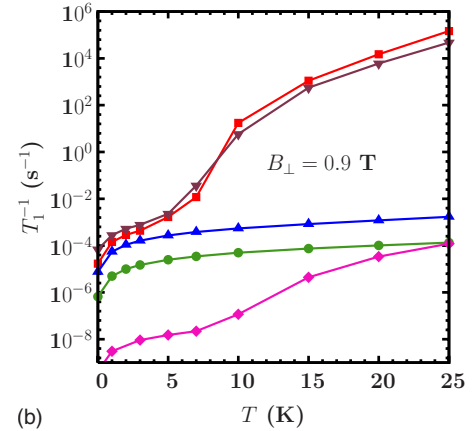
FIG. 11. (Color online) Spin relaxation time T_1 , spin dephasing time T_2 , and T_1/T_2 against temperature T . $B_{\perp}=4$ T, $a=5$ nm, and $d_0=30$ nm. Note that the scale of T_1 and T_2 is at the right hand side of the frame.

al. have shown via perturbation theory that the phonon induces only the spin-flip noise in the leading order. Consequently, $T_2=2T_1$.²⁰ When the temperature becomes comparable to the orbital level splitting $\hbar\omega_0$, the distribution over the upper orbital levels is not negligible anymore. As mentioned previously, the SOC contributes a nontrivial part to the Zeeman splitting. Specifically, the second-order energy correction due to the SOC contributes to the Zeeman splitting. The energy correction for different orbital levels is generally unequal (always larger for higher levels). When the electron is scattered by phonons randomly from one orbital state to another one with the same major spin polarization, the frequency of its precession around the z direction changes. Continuous scattering leads to a random fluctuation of the precession frequency and thus leads to spin dephasing.^{29,46} Note that this fluctuation only leads to a phase randomization of S_+ but not flips the z component spin S_z , i.e., not leads to a spin relaxation. Therefore, the spin dephasing becomes stronger than the spin relaxation for high temperatures. Moreover, this effect increases with temperature rapidly as the distribution over higher levels and the phonon numbers both increase with temperature.

We further study the temperature dependence of spin relaxation for lower magnetic field and larger quantum well width where other mechanisms may be more important than the electron-BP mechanism. In Fig. 12(a), the spin relaxation time is plotted as a function of temperature for $B_\perp=0.5$ T, $a=10$ nm, and $d_0=20$ nm. It is seen from the figure that the direct spin-phonon coupling due to the phonon-induced strain mechanism dominates the spin relaxation throughout the temperature range. It is also noted that for $T\leq 4$ K, the spin relaxation rates induced by different mechanisms all increase with temperature according to the phonon number factor $2\bar{n}(E_{z1})+1$ with E_{z1} being the Zeeman splitting of the lowest Zeeman sublevels. However, for $T>4$ K, the spin relaxation rates induced by the direct spin-phonon coupling due to phonon-induced strain and the electron-BP interaction increase rapidly with temperature, while the spin relaxation rates induced by $V_{el-ph}^{(1)}$ and $V_{el-ph}^{(3)}$ increase mildly according to $2\bar{n}(E_{z1})+1$ throughout the temperature range. These features can be understood as follows. For $T\leq 4$ K, the distribution over the high levels is negligible. Only the lowest two Zeeman sublevels are involved in the spin dynamics. The spin relaxation rates thus increase with $2\bar{n}(E_{z1})+1$ and the relative importance of each mechanism does not change. Therefore, our previous analysis on the comparison of the relative importance of different spin decoherence mechanisms at 4 K holds true for the range $0\leq T\leq 4$ K. When the temperature gets higher, the contribution from higher levels becomes more important. Although the distribution at the higher levels is still very small, for the direct spin-phonon coupling mechanism, the transition rates between the higher levels and those between higher levels and the lowest two sublevels are very large. For the electron-BP mechanism, the transition rates between the higher levels are very large due to the large SOC in these levels. Therefore, the contribution from the higher levels becomes larger than that from the lowest two sublevels. Consequently, the increase of temperature leads to a rapid increase of the spin relaxation rates.



(a)



(b)

FIG. 12. (Color online) Spin relaxation time T_1 against temperature T for (a) $B_\perp=0.5$ T and (b) $B_\perp=0.9$ T. $a=10$ nm and $d_0=20$ nm. Curves with (■)— T_1^{-1} induced by the electron-BP scattering together with the SOC. Curves with (●)— T_1^{-1} induced by the second-order process of the hyperfine interaction together with the BP ($V_{el-ph}^{(3)}$). Curves with (▲)— T_1^{-1} induced by the first-order process of the hyperfine interaction together with the BP ($V_{el-ph}^{(1)}$). Curves with (▼)— T_1^{-1} induced by the direct spin-phonon coupling due to phonon-induced strain. Curves with (◆)— T_1^{-1} induced by the g -factor fluctuation.

However, for the two hyperfine mechanisms, the $V_{el-ph}^{(1)}$ and the $V_{el-ph}^{(3)}$, the spin relaxation rates do not change much when the higher levels are involved. They thus increase by the phonon number factor.

In Fig. 12(b), we show the temperature dependence of the spin relaxation time for the same condition but with $B=0.9$ T. It is noted that the spin relaxation rate due to the electron-BP mechanism catches up with that induced by the direct spin-phonon coupling due to phonon-induced strain at $T=9$ K and becomes larger for higher temperature. This indicates that the temperature dependence of the two mechanisms is quite different.

In Fig. 13, we show the spin dephasing induced by electron-BP scattering and the hyperfine interaction as a function of temperature for $B_\perp=4$ T, $a=10$ nm, and $d_0=20$ nm. We choose the conditions so that the spin dephasing is dominated by the hyperfine interaction at low temperature. However, the effect of the electron-BP mechanism increases

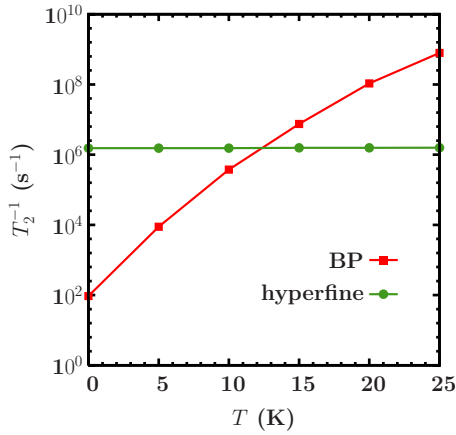


FIG. 13. (Color online) Spin relaxation time T_1 against temperature T . $B_{\perp}=4$ T, $a=10$ nm, and $d_0=20$ nm. Curves with (■)— T_2^{-1} induced by the electron-BP scattering together with the SOC. Curves with (●)— T_2^{-1} induced by the hyperfine interaction.

with temperature quickly, while that of the hyperfine interaction remains nearly unchanged. The fast increase of the effect from the electron-BP scattering is due to three factors: (1) the increase of the phonon number, (2) the increase of scattering channels, and (3) the increase of the SOC induced spin mixing in higher levels. On the other hand, from Eq. (35), one can deduce that the spin dephasing rate of the hyperfine interaction depends mainly on the factor $1/(a_z d_{\parallel}^2)$ with a_z (d_{\parallel}^2) is the characteristic length (area) along the z direction (in the quantum well plane). For higher levels, the d_{\parallel}^2 is larger but only about a factor smaller than 10. Thus, the effect of the hyperfine interaction increases very slowly with temperature.

It should be noted that in the above discussion, we neglected the two-phonon scattering mechanism,^{15,46,50} which may be important at high temperature. The contribution of this mechanism should be calculated via the equation-of-motion approach developed in this paper and compared with the contribution of other mechanisms showed here.

VI. CONCLUSION

In conclusion, we have investigated the longitudinal and transversal spin decoherence times T_1 and T_2 , called spin relaxation time and spin dephasing time, in different conditions in GaAs QDs from the equation-of-motion approach. Various mechanisms, including the electron-BP scattering, the hyperfine interaction, the direct spin-phonon coupling due to phonon-induced strain and the g -factor fluctuation, are considered. Their relative importance is compared. There is no doubt that for spin decoherence induced by electron-BP scattering, the SOC must be included. However, for spin decoherence induced by the hyperfine interaction, the direct spin-phonon coupling due to phonon-induced strain, g -factor fluctuation, and hyperfine interaction combined with electron-phonon scattering, the SOC is neglected in the existing literature.^{27,28,45} Our calculations have shown that, as the SOC has marked effect on the eigenenergy and the eigen-

wave-function of the electron, the spin decoherence induced by these mechanisms with the SOC is larger than that without it. Especially, the decoherence from the second-order process of hyperfine interaction combined with the electron-BP interaction increases at least 1 order of magnitude when the SOC is included. Our calculations show that, with the SOC, in some conditions some of these mechanisms (except g -factor fluctuation mechanism) can even dominate the spin decoherence.

There is no single mechanism which dominates spin relaxation or spin dephasing in all parameter regimes. The relative importance of each mechanism varies with the well width, magnetic field, and QD diameter. In particular, the electron-BP scattering mechanism has the largest contribution to spin relaxation and spin dephasing for small well width and/or high magnetic field and/or large QD diameter. However, for other parameters, the hyperfine interaction, the first-order process of the hyperfine interaction combined with electron-BP scattering, and the direct spin-phonon coupling due to phonon-induced strain can be more important. It is noted that the g -factor fluctuation always has very little contribution to spin relaxation and spin dephasing which can thus be neglected all the time. For spin dephasing, the electron-BP scattering mechanism and the hyperfine interaction mechanism are more important than other mechanisms for magnetic field higher than 3.5 T. For this regime, other mechanisms can thus be neglected. It is also shown that spin dephasing induced by the electron-BP mechanism increases rapidly with temperature. Extrapolated from our calculation, the hyperfine interaction mechanism is believed to be dominant for small magnetic field.

We also discussed the problem of finding a proper method to average over the transition rates $\tau_{i \rightarrow f}^{-1}$ obtained from the Fermi golden rule to give the spin relaxation time T_1 at finite temperature. For small SOC, we rederived the formula for T_1 at finite temperature used in the existing literature^{18,51,52} from the equation of motion. We further demonstrated that this formula is inadequate at high temperature and/or for large SOC. For such cases, a full calculation from the equation-of-motion approach is needed. The equation-of-motion approach provides an easy and powerful way to calculate the spin decoherence at *any* temperature and SOC.

We also studied the temperature dependence of spin relaxation T_1 and dephasing T_2 . We show that for very low temperature if the electron only distributes on the lowest two Zeeman sublevels, $T_2=2T_1$. However, for higher temperatures, the electron spin dephasing increases with temperature much faster than the spin relaxation. Consequently, $T_1 \gg T_2$. The spin relaxation and dephasing due to different mechanisms are also compared.

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- ¹*Semiconductor Spintronics and Quantum Computation*, edited by D. D. Awschalom, D. Loss, and N. Samarth (Springer-Verlag, Berlin, 2002); I. Zutic, J. Fabian, and S. Das Sarma, *Rev. Mod. Phys.* **76**, 323 (2004).
 - ²H.-A. Engel, L. P. Kouwenhoven, D. Loss, and C. M. Marcus, *Quantum Inf. Process.* **3**, 115 (2004); D. Heiss, M. Kroutvar, J. J. Finley, and G. Abstreiter, *Solid State Commun.* **135**, 591 (2005), and references therein.
 - ³D. Loss and D. P. DiVincenzo, *Phys. Rev. A* **57**, 120 (1998).
 - ⁴R. Hanson, L. P. Kouwenhoven, J. R. Petta, S. Tarucha, and L. M. K. Vandersypen, *Rev. Mod. Phys.* **79**, 1217 (2007).
 - ⁵J. M. Taylor, H.-A. Engel, W. Dür, A. Yacoby, C. M. Marcus, P. Zoller, and M. D. Lukin, *Nat. Phys.* **1**, 177 (2005).
 - ⁶S. Amasha, K. MacLean, I. Radu, D. M. Zumbuhl, M. A. Kastner, M. P. Hanson, and A. C. Gossard, arXiv:cond-mat/0607110 (unpublished).
 - ⁷J. M. Elzerman, R. Hanson, L. H. Willems van Beveren, B. Witkamp, L. M. K. Vandersypen, and L. P. Kouwenhoven, *Nature (London)* **430**, 431 (2004).
 - ⁸D. Paget, G. Lample, B. Sapoval, and V. I. Safarov, *Phys. Rev. B* **15**, 5780 (1977).
 - ⁹*Optical Orientation*, edited by F. Meier and B. P. Zakharchenya (North-Holland, Amsterdam, 1984).
 - ¹⁰G. Dresselhaus, *Phys. Rev.* **100**, 580 (1955).
 - ¹¹Y. Bychkov and E. I. Rashba, *J. Phys. C* **17**, 6039 (1984).
 - ¹²L. M. Roth, *Phys. Rev.* **118**, 1534 (1960).
 - ¹³A. V. Khaetskii and Y. V. Nazarov, *Physica E (Amsterdam)* **6**, 470 (2000).
 - ¹⁴A. V. Khaetskii and Y. V. Nazarov, *Phys. Rev. B* **61**, 12639 (2000).
 - ¹⁵A. V. Khaetskii and Y. V. Nazarov, *Phys. Rev. B* **64**, 125316 (2001).
 - ¹⁶L. M. Woods, T. L. Reinecke, and Y. Lyanda-Geller, *Phys. Rev. B* **66**, 161318(R) (2002).
 - ¹⁷R. de Sousa and S. Das Sarma, *Phys. Rev. B* **68**, 155330 (2003).
 - ¹⁸J. L. Cheng, M. W. Wu, and C. Lü, *Phys. Rev. B* **69**, 115318 (2004).
 - ¹⁹D. V. Bulaev and D. Loss, *Phys. Rev. B* **71**, 205324 (2005).
 - ²⁰V. N. Golovach, A. Khaetskii, and D. Loss, *Phys. Rev. Lett.* **93**, 016601 (2004).
 - ²¹C. F. Destefani and S. E. Ulloa, *Phys. Rev. B* **72**, 115326 (2005).
 - ²²P. San-Jose, G. Zarand, A. Shnirman, and G. Schön, *Phys. Rev. Lett.* **97**, 076803 (2006).
 - ²³V. I. Fal'ko, B. L. Altshuler, and O. Tsypliyatev, *Phys. Rev. Lett.* **95**, 076603 (2005).
 - ²⁴P. Stano and J. Fabian, *Phys. Rev. Lett.* **96**, 186602 (2006).
 - ²⁵P. Stano and J. Fabian, *Phys. Rev. B* **74**, 045320 (2006).
 - ²⁶H. Westfahl, Jr., A. O. Caldeira, G. Medeiros-Ribeiro, and M. Cerro, *Phys. Rev. B* **70**, 195320 (2004).
 - ²⁷S. I. Erlingsson and Yuli V. Nazarov, *Phys. Rev. B* **66**, 155327 (2002).
 - ²⁸V. A. Abalmassov and F. Marquardt, *Phys. Rev. B* **70**, 075313 (2004).
 - ²⁹Y. G. Semenov and K. W. Kim, *Phys. Rev. Lett.* **92**, 026601 (2004).
 - ³⁰A. V. Khaetskii, D. Loss, and L. Glazman, *Phys. Rev. Lett.* **88**, 186802 (2002).
 - ³¹A. Khaetskii, D. Loss, and L. Glazman, *Phys. Rev. B* **67**, 195329 (2003).
 - ³²J. Schliemann, A. Khaetskii, and D. Loss, *J. Phys.: Condens. Matter* **15**, R1809 (2003) and references therein.
 - ³³W. A. Coish and D. Loss, *Phys. Rev. B* **70**, 195340 (2004).
 - ³⁴Ö. Cakir and T. Takagahara, *Physica E (Amsterdam)* **40**, 379 (2007).
 - ³⁵C. Deng and X. Hu, arXiv:cond-mat/0608544 (unpublished).
 - ³⁶S. I. Erlingsson and Yuli V. Nazarov, *Phys. Rev. B* **70**, 205327 (2004).
 - ³⁷N. Shenvi, R. de Sousa, and K. B. Whaley, *Phys. Rev. B* **71**, 224411 (2005).
 - ³⁸R. de Sousa, in *Electron Spin Resonance and Related Phenomena in Low Dimensional Structures*, edited by M. Fanciulli (Springer-Verlag, Berlin, 2007).
 - ³⁹Y. V. Pershin and V. Privman, *Nano Lett.* **3**, 695 (2003).
 - ⁴⁰I. A. Merkulov, A. L. Efros, and M. Rosen, *Phys. Rev. B* **65**, 205309 (2002).
 - ⁴¹W. M. Witzel, R. de Sousa, and S. Das Sarma, *Phys. Rev. B* **72**, 161306(R) (2005).
 - ⁴²W. Yao, R.-B. Liu, and L. J. Sham, *Phys. Rev. B* **74**, 195301 (2006).
 - ⁴³W. M. Witzel and S. Das Sarma, *Phys. Rev. B* **74**, 035322 (2006).
 - ⁴⁴C. Deng and X. Hu, *Phys. Rev. B* **73**, 241303(R) (2006).
 - ⁴⁵Y. G. Semenov and K. W. Kim, *Phys. Rev. B* **70**, 085305 (2004).
 - ⁴⁶Y. G. Semenov and K. W. Kim, *Phys. Rev. B* **75**, 195342 (2007).
 - ⁴⁷W. M. Witzel and S. Das Sarma, *Phys. Rev. Lett.* **98**, 077601 (2007).
 - ⁴⁸R. de Sousa, N. Shenvi, and K. B. Whaley, *Phys. Rev. B* **72**, 045330 (2005).
 - ⁴⁹J. H. Jiang and M. W. Wu, *Phys. Rev. B* **75**, 035307 (2007).
 - ⁵⁰B. A. Glavin and K. W. Kim, *Phys. Rev. B* **68**, 045308 (2003).
 - ⁵¹C. Lü, J. L. Cheng, and M. W. Wu, *Phys. Rev. B* **71**, 075308 (2005).
 - ⁵²Y. Y. Wang and M. W. Wu, *Phys. Rev. B* **74**, 165312 (2006).
 - ⁵³W. H. Lau and M. E. Flatté, *Phys. Rev. B* **72**, 161311(R) (2005).
 - ⁵⁴C. P. Slichter, *Principles of Magnetic Resonance* (Springer-Verlag, Berlin, 1990).
 - ⁵⁵T. Fujisawa, D. G. Austing, Y. Tokura, Y. Hirayama, and S. Tarucha, *Nature (London)* **419**, 278 (2002).
 - ⁵⁶See, e.g., P. N. Argyres and P. L. Kelley, *Phys. Rev.* **134**, A98 (1964).
 - ⁵⁷R. L. Fulton, *J. Chem. Phys.* **41**, 2876 (1964).
 - ⁵⁸P.-F. Braun, X. Marie, L. Lombez, B. Urbaszek, T. Amand, P. Renucci, V. K. Kalevich, K. V. Kavokin, O. Krebs, P. Voisin, and Y. Masumoto, *Phys. Rev. Lett.* **94**, 116601 (2005).
 - ⁵⁹F. H. L. Koppens, J. A. Folk, J. M. Elzerman, R. Hanson, L. H. Willems van Beveren, I. T. Vink, H. P. Tranitz, W. Wegscheider, L. P. Kouwenhoven, and L. M. K. Vandersypen, *Science* **309**, 1346 (2005).
 - ⁶⁰J. R. Petta, A. C. Johnson, J. M. Taylor, E. A. Laird, A. Yacoby, M. D. Lukin, C. M. Marcus, M. P. Hanson, and A. C. Gossard, *Science* **309**, 2180 (2005).
 - ⁶¹F. H. L. Koppens, K. C. Nowack, and L. M. K. Vandersypen, arXiv:0711.0479 (unpublished).
 - ⁶²M. W. Wu and H. Metiu, *Phys. Rev. B* **61**, 2945 (2000).
 - ⁶³T. Kuhn and F. Rossi, *Phys. Rev. Lett.* **69**, 977 (1992).
 - ⁶⁴J. Shah, *Ultrafast Spectroscopy of Semiconductors and Semiconductor Nanostructures* (Springer, Berlin, 1996).
 - ⁶⁵M. I. D'yakonov and V. I. Perel', *Zh. Eksp. Teor. Fiz.* **60**, 1954 (1971) [*Sov. Phys. JETP* **33**, 1053 (1971)].

- ⁶⁶A. Abragam, *The Principles of Nuclear Magnetism* (Oxford University Press, Oxford, 1961), Chaps. VI and IX.
- ⁶⁷This can be obtained from Eq. (17) in Ref. 42.
- ⁶⁸*Semiconductors*, Landolt-Börnstein, New Series, Vol. 17a, edited by O. Madelung (Springer-Verlag, Berlin, 1987).
- ⁶⁹W. Knap, C. Skierbiszewski, A. Zduniak, E. Litwin-Staszewska, D. Bertho, F. Kobbi, J. L. Robert, G. E. Pikus, F. G. Pikus, S. V. Iordanskii, V. Mosser, K. Zekentes, and Yu. B. Lyanda-Geller, *Phys. Rev. B* **53**, 3912 (1996).
- ⁷⁰It should be mentioned that one effect is not included: when the electron is scattered by the phonon from one orbital state to

another, it feels a difference in the spin precession frequency since the strength of longitudinal (along the external magnetic field) component of the Overhauser field differs with orbital states. This effect randomizes the spin precession phase and leads to a pure spin dephasing. However, this effect is negligible in our paper.

- ⁷¹The deviation of our calculation from the experimental data at $T=14$ T is due to the fact that we do not include the cyclotron effect along the z , direction. For $B \approx 10$ T, the cyclotron orbit length is smaller than the quantum well width, which makes our model unrealistic.